

CHAPTER 3

ELECTRODEPOSITION OF SINGLE METALS

( Zinc and Tin )

!

### 3.1 Electrodeposition of Single Metals ( Zinc and Tin ) :

Deposition of most metals from aqueous solutions especially at platinum cathode takes place with very little overvoltage and hence at essentially reversible potentials. Had there been only the metal ions as the cations, these potentials would alone determine the process of deposition. However, in any aqueous solution hydrogen ions are also present, and consequently two cathodic reactions are possible, the deposition of the metal and the evolution of hydrogen. Hence it is of great interest to study the conditions under which a metal can be deposited from aqueous solution before evolution of hydrogen sets in. If the potential required for metal deposition is less than that for the hydrogen ( or the reduction potential of the metal higher than that of hydrogen discharge at the cathode), the product of electrolysis at the cathode will be the metal. If the reverse is true, cathodic liberation of hydrogen will occur. However, whereas the cathodic deposition of metals involves only the reversible metal electrode potentials, the liberation of hydrogen involves not only the reversible potential of the hydrogen electrode in the particular solution, but also the overvoltage of hydrogen at the material composing the cathode. In fact, it is because of this factor that many metals ( basic in particular ) can be deposited, from aqueous solutions in preference to hydrogen, due to overvoltage of the latter.

It can readily be shown that in a neutral aqueous solution ( pH = 7 ) the potential for the reversible evolution of hydrogen would be -

$$E_{H_2} = E^{\circ} - \frac{0.059}{1} \log \frac{1}{10^{-7}} = - 0.41 \text{ volt.}$$

On the other hand, the deposition of most metals above hydrogen in E.M. Series would be impossible, were it not for overvoltage. For example, the deposition potentials for metals such as Zn ( = 0.762 volt ) or Sn ( = 0.140 volt ) suggest that hydrogen would preferentially be discharged first or alongwith the metals. But it has been shown that hydrogen overvoltage at copper or other cathode is much above the stated value. Consequently in order to discharge hydrogen from neutral solutions or even acidic ones containing the zinc or tin salts, a potential of about 1.0 volt would be necessary and as such the metals can easily be plated with relatively lower voltages without the gas evolution.

### 3.2 Electrodeposition of Zinc from Thiocyanate Bath :

Zinc can be deposited from both acid and alkaline baths. The acid baths consist of sulphate, chloride or fluoborate and the alkaline baths usually contain both cyanide<sup>(27)</sup> and zincate. ~~Phosphate~~ phosphate baths are also alkaline. The alkaline baths have better throwing power and are therefore most commonly used to plate irregularly shaped articles. The acid baths are used to plate wire and sheet metal, where good throwing power is not required. Cyanide baths cannot be used to deposit zinc directly on malleable or cast iron unless special steps are taken in the preparation of the basic metals.

As indicated in introduction, hydrogen is much more easily discharged than zinc, as the potential of zinc is over 0.7 volt more negative than that of hydrogen. It appears therefore that it would be impossible to deposit zinc, at least with any good cathode efficiency, from acid solutions. The fact that it is possible to do so, depends upon the high over voltage of hydrogen on zinc. Actually as in Tainton process, zinc can be deposited with high cathode efficiencies from strongly acid solutions, provided they are pure. The presence of very small amounts of certain metals such as cobalt and nickel, lowers the overvoltage of hydrogen on zinc and greatly decreases the cathode efficiency.

It is the objective of the present work, to obtain good quality deposit of zinc on copper from thiocyanate bath (alkaline) which is very simple to prepare, with good throwing power and satisfactory CTE, so as to make the process commercially useful.

The following plating parameters were studied in order to obtain a good quality, lustrous and fine deposit.

- 1) <sup>con</sup>Concentration of the electrolytes,
- 2) Current density,
- 3) Temperature,
- 4) Duration of electrolysis,
- 5) Electrode distance,
- 6) Addition agents.

### 3.2.1 Brief Review of the Earlier Work :

Thousands of Papers on electrodeposition of single metals are available. However the present review is confined to the deposition of Zinc and Tin.

### 3.2.2 Earlier Work on Electrodeposition of Zinc :

Cyanide zinc plating dates from World war-I, when the throwing power of the sulfate process was inadequate for plating steel shell castings. Commercial possibilities for the process were recognized and bath composition not too early postwar years by porctor and Wenlund ( 28 ) and Blum et al ( 29 ). Developmental highlights include the introduction by oplinger ( 30 ) of polysulfide for protection against metallic contamination. The historical aspects and performance of the more dilute baths are discussed by Bair ( 31 ) and Du Rose ( 32 ). A bath for electroplating of bright to semi-bright zinc of the acid chloride, acid sulphate, acid fluoborates, acid acetic acid sulphate, alkaline zincate or alkaline cyanide type is described by Martin sylvia and co-workers ( 33 ). Similarly Buchette, Michel and others ( 34 ) gave the alkaline bath for electrodeposition of zinc, containing sodium hydroxide as main constituent and glyconic acid as complexing agent. Ammoniacal tetrafluoborate bath was given by Lushit ( 35 ) and others. Similar type of work has been done on different baths. Recently, quite promising work has been carried out on zinc deposition in relation to industrial aspects, addition agents structure etc. ( 36-54 ).

TABLE I - The effect of concentration of zinc sulphate on the metal content and the percentage cathode current efficiency (see 3) of the zinc deposit.

Potassium thiocyanate : 5 gms per 100 ml.  
 Current density : 1.6 amps per sq. cm.  
 Duration of electrolysis : 20 minutes  
 Voltage : 1.9 to 2 volts.

Doric acid : 1 gm. per 100 ml.  
 Temperature : 30°C  
 Electrode distance : 4 cms.

Sr. No.	Concn. of zinc sulphate (gms. per 100 ml.)	Wt. of copper deposited (in gms.)	Wt. of zinc deposited in coulometer (gms.)	CCE %	(Mean)	Nature of deposit
1	5	0.065	0.024	35.91	(38)	Dull and adherent, black at the edges.
2	10	0.066	0.026	40.00	(41)	Uniform good, adherent and white bright.
3	15	"	"	"	"	Not so good but quite satisfactory.
4	20	0.069	0.036	51.01	(52)	Spongy, non adherent and black.
5	30	0.067	0.037	53.21	(61)	" " " "
6	40	0.077	0.047	59.36	(65)	" " " "
		0.075	0.046	62.46		
		0.053	0.052	60.17		" " - unsatisfactory.
		0.062	0.062	69.66		

\* Optimum condition.

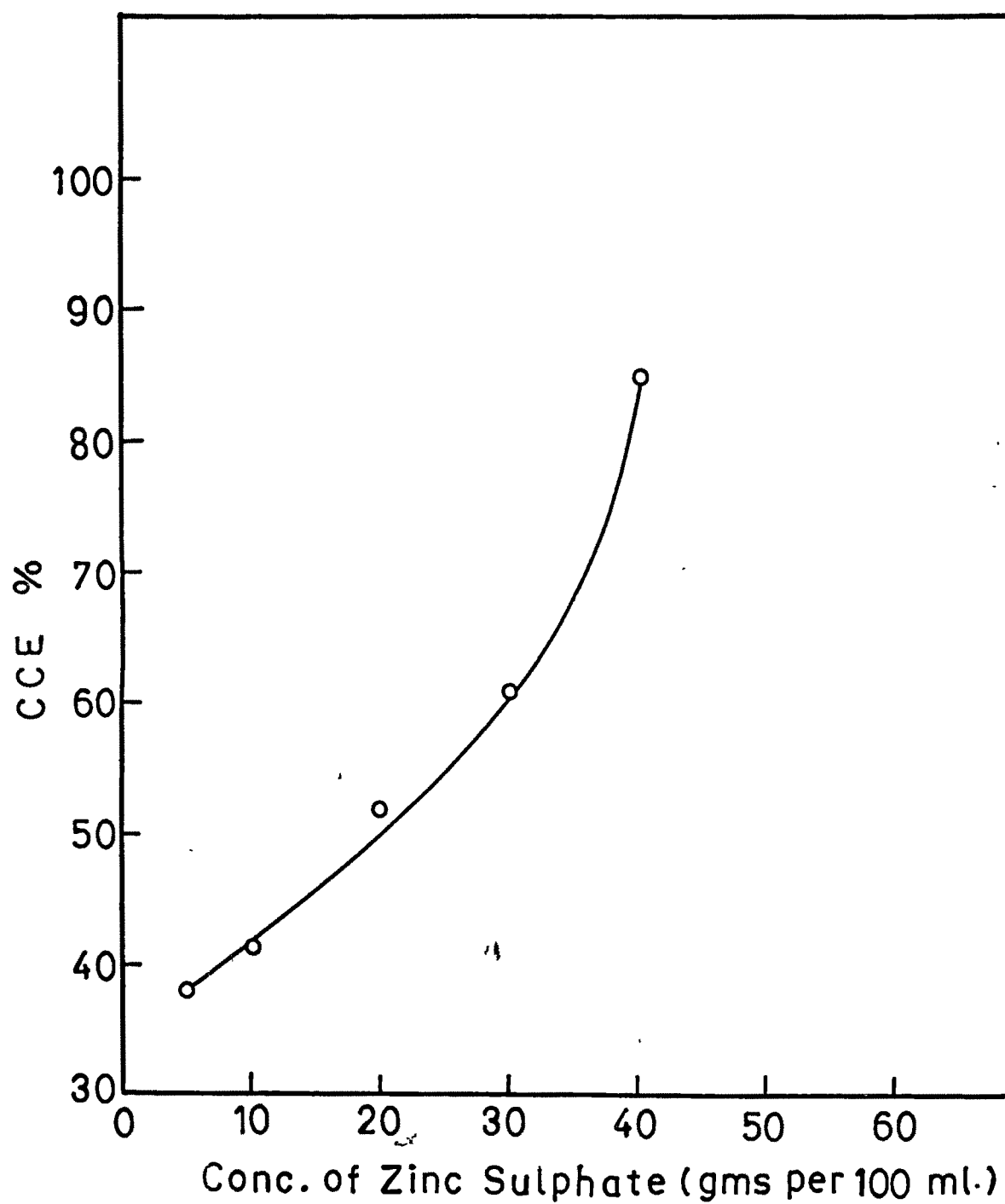


Fig.1—Effect of Zinc Sulphate concentration on cathode current efficiency(CCE %) of Zinc deposit .



TABLE NO. 2 :- The effect of concentration of potassium thiocyanate on the metal content and the percentage cathode current efficiency ( CCE % ) of the Zinc deposit.

Zinc sulphate : 10 gms. per 100 ml.      Boric acid : 1 gm. per 100 ml.  
 Current density : 1.5 amps per sq. dm.      Temperature : 30°C.  
 Duration of electrolysis : 30 minutes      Electrode distance : 4 cms.  
 Voltage : 1.9 to 1.7 volts.

Sr. No.	Conc. of K <sub>2</sub> C <sub>2</sub> O <sub>4</sub> gms per 100 ml.	wt. of copper deposited in coulometer gm.	wt. of zinc deposited gm.	Percentage CCE	Nature of deposit
1	-	-	-	-	Not satisfactory ( dull deposit )
2	0.065	0.024	0.024	35.91 (33)	Uniform good adherent and bright
3	0.062	0.024	0.024	37.64 (37.0)	Improvement in quality.
4	0.063	0.024	0.025	38.2 (40.0)	Good deposit but blackening & trailing as time proceeds.
5	0.066	0.025	0.025	41.00 (45.0)	-- do --
6	0.071	0.031	0.031	45.69 (60)	Adherent but non-uniform and spatchy.
	0.055	0.040	0.040	70.73	
	0.061	0.042	0.042	66.95	

\* Optimum condition.

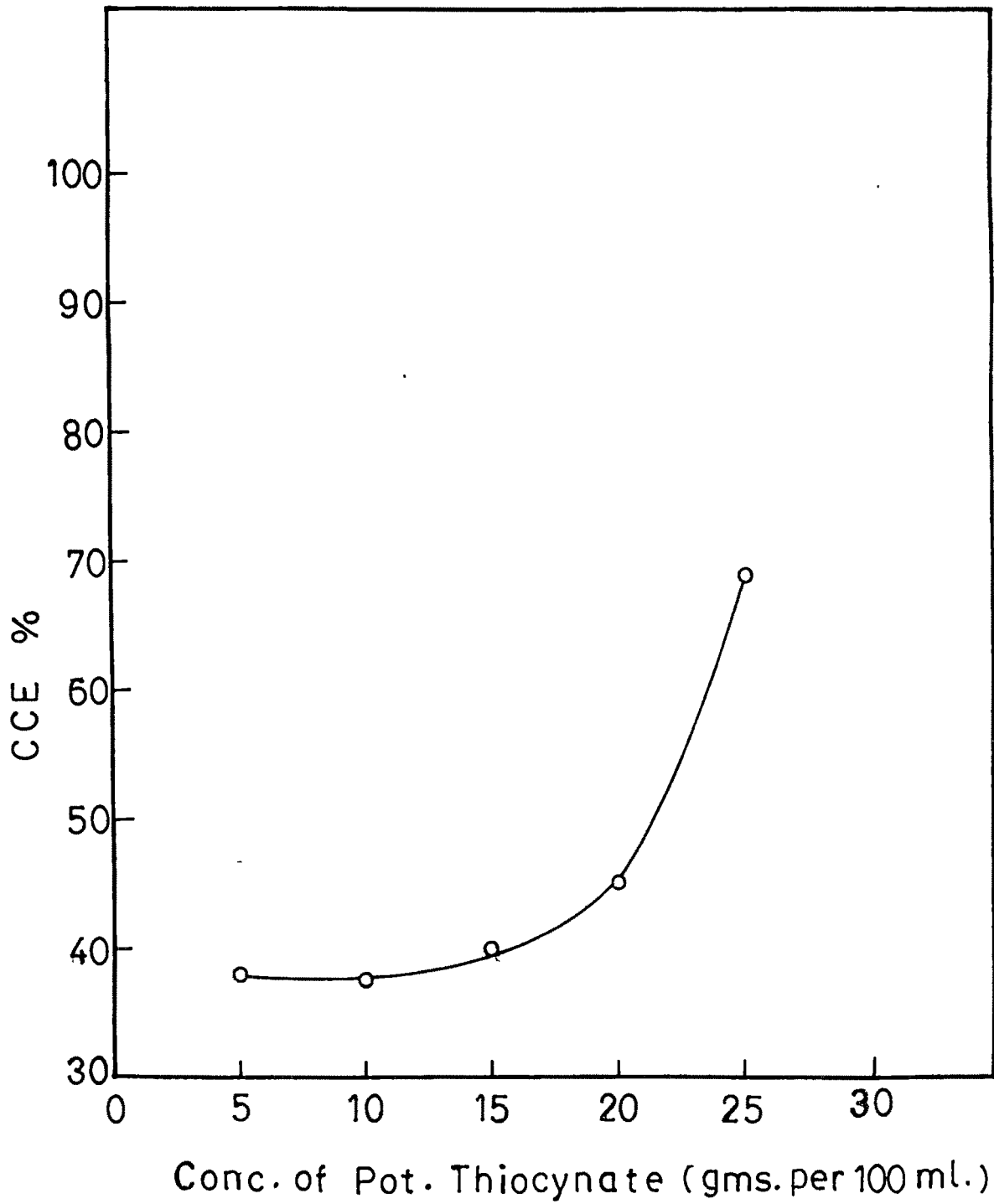


Fig.2 — Effect of Potassium Thiocyanate concentration on cathode current efficiency (CCE %) of Zinc deposit .

TABLE NO. 3 :- The effect of concentration of Boric acid on the metal content and the percentage cathode current efficiency ( C.E. ) of the Zinc deposit.

Zinc Sulphate : 10 gms. per 100 ml. Potassium thiocyanate : 10 gms. per 100 ml.  
 Current density : 1.6 amps per sq. dm. Temperature : 30 °C.  
 Duration of electrolysis : 20 minutes Electrode distance : 4 cms.  
 Voltage : 1.9 to 2 volts.

Gr. Co.	Conc. of Boric acid gms. per 100 ml.	Wt. of copper deposited in crucible gms.	Wt. of Zinc. gms.	Percentage C.E.	Nature of deposit.
1	0.050	0.019	0.019	33.07 (34)	Uniform white bright, smooth and adherent.
2	0.050	0.019	0.019	35.91	
3	0.054	0.043	0.043	77.45 (76)	Deposit improved in quality.
4	0.053	0.041	0.041	75.26	
5	0.062	0.031	0.031	50.0 (50)	Uniform but slightly black.
6	0.062	0.031	0.031	50.0	
7	0.060	0.023	0.023	37.17 (36)	
8	0.060	0.020	0.020	35.86	
9	0.051	0.021	0.021	33.17 (33)	Spongy, spatchy & unsatisfactory.
10	0.050	0.020	0.020	32.06	

\* Optical condition.  
 Cf plate 1

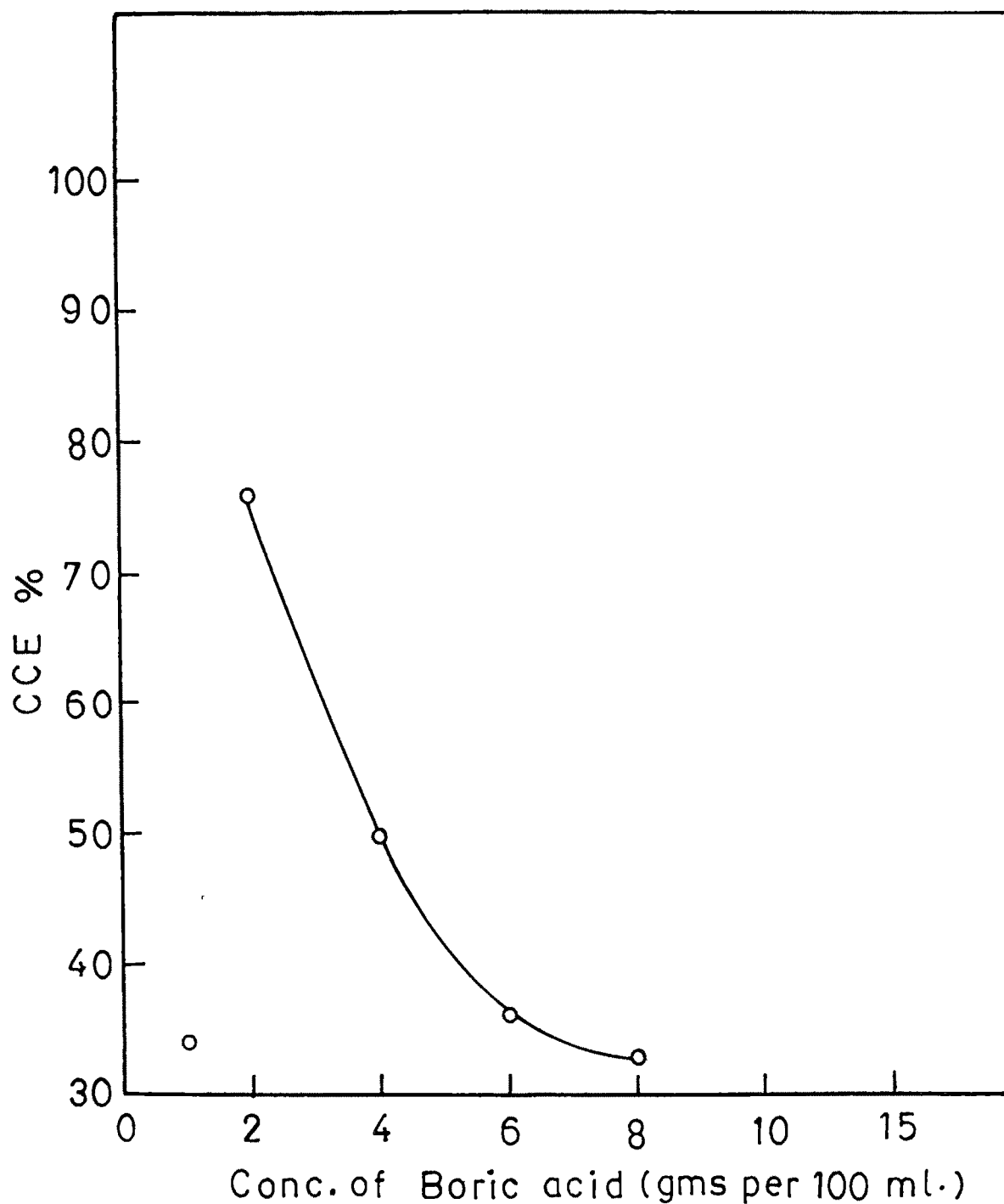


Fig.3—Effect of Boric acid concentration on cathode current efficiency (CCE %) of Zinc deposit .



TABLE NO. 4 :- The effect of current density on the metal content and the percentage cathode current efficiency ( c.c.s % ) of the zinc deposit.

Sinc sulphate : 10 grs. per 100 ml.      Potassium thiocyanate : 10 grs. per 100 ml.  
 Sulfuric acid : 2 grs. per 100 ml.      Temperature : 30°C  
 Duration of electrolysis : 20 minutes      Electrode distance : 4 cms.  
 Voltage : 1.7 to 2 volts.

Sl. No.	Current density amp. per sq. cm.	Nt. of copper deposited in coulometer grs.	Nt. of zinc deposited grms.	Percentage c.c.s	Nature of deposit.
1.	0.3	0.032	0.012	36.12 (39)	Spotty with black spot, unsatisfactory.
2	1.5	0.030	0.013	41.76	Uniform, bright and smooth deposit.
* 3	2.4	0.066	0.032	46.72 (47)	Bright, adherent, uniform, quite good.
+ 4	3.2	0.064	0.033	49.69	Smooth but slightly black.
		0.081	0.051	50.87 (50.5)	
		0.030	0.051	61.42	
		0.127	0.083	62.97 (64)	
		0.105	0.072	66.07	
5	4.0	0.130	0.113	83.76 (82)	Unsatisfactory. Spongy non-adherent, black with tracing at edges.
		0.134	0.114	81.97	

\* Optimum condition.  
 + cf Plate 2

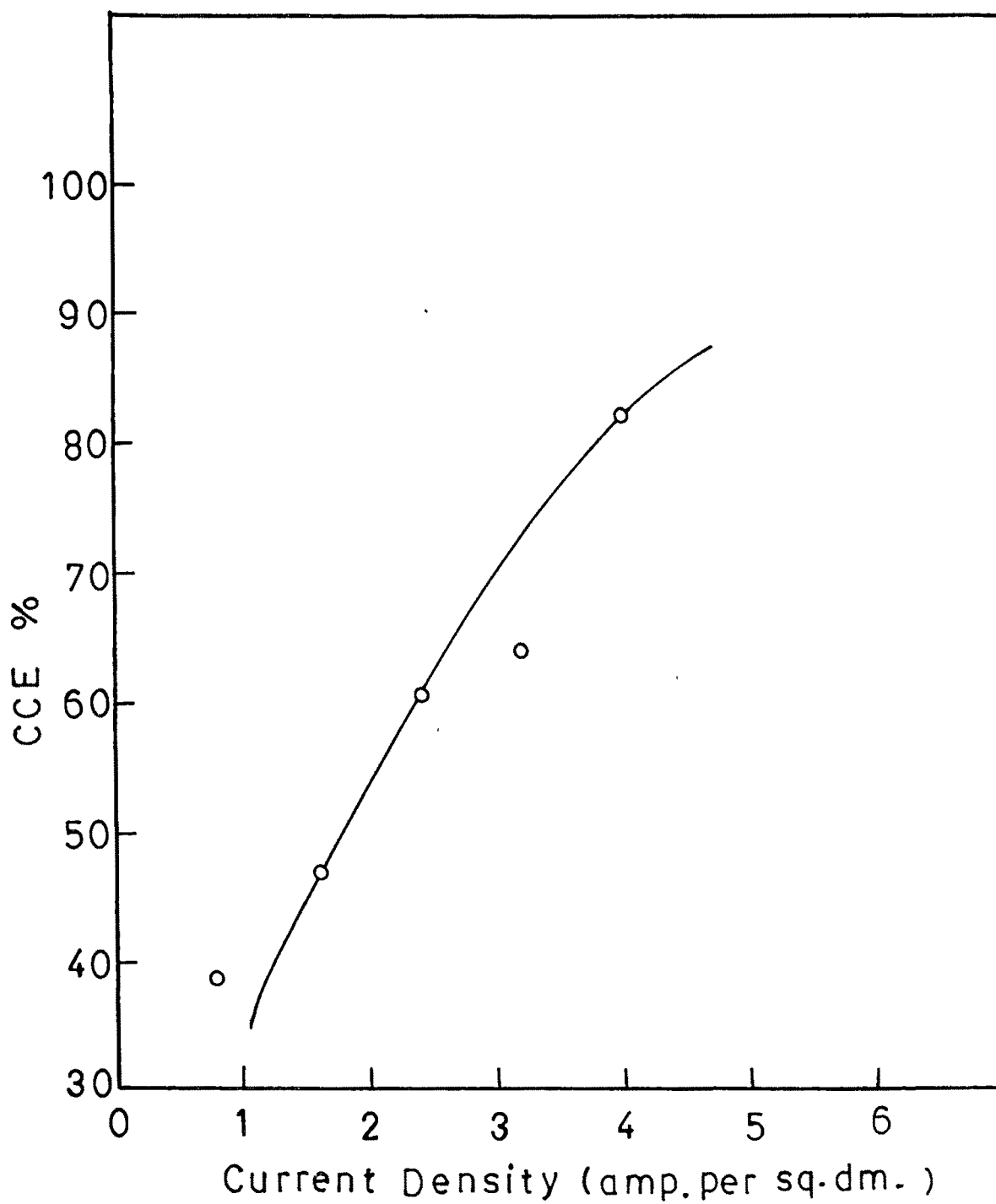


Fig. 4 — Effect of current density on cathode current efficiency (CCE %) of Zinc deposit.

TABLE NO. 5 - The effect of temperature on the metal content and the percentage cathode current efficiency ( C.C. % ) of the zinc deposit.

Zinc sulphate : 10 gms. per 100 ml. Potassium thiocyanate : 10 gms. per 100 ml.  
 Soric acid : 2 gms. per 100 ml. Current density : 2.4 amp per sq.cm.  
 Duration of electrolysis : 20 minutes. Electrode distance : 4 cms.  
 Voltage : 2 volts.

Gr. No.	Temp. Cc.	Wt. of copper deposited in coulometer	Wt. of zinc deposited (gms.)	Percentage C.C.	Nature of deposit
1	10	0.054	0.041	73.03 (73)	Non uniform but adherent.
2	20	0.055	0.041	72.49	Good deposit but not uniform
3	30	0.050	0.037	62.01 (63)	Smooth bright and adherent.
		0.052	0.035	64.57	
4	40	0.065	0.032	47.15 (48)	Good deposit but slightly black. Slight evolution of gas.
		0.060	0.033	50.00	
5	50	0.061	0.026	39.13 (40)	Good deposit but slightly black. Slight evolution of gas.
		0.065	0.027	40.00	
		0.061	0.020	65.68 (44)	Dull and rough deposit. Not satisfactory.
		0.062	0.027	42.36	

\* Optimum condition.  
 cf Plate 3.

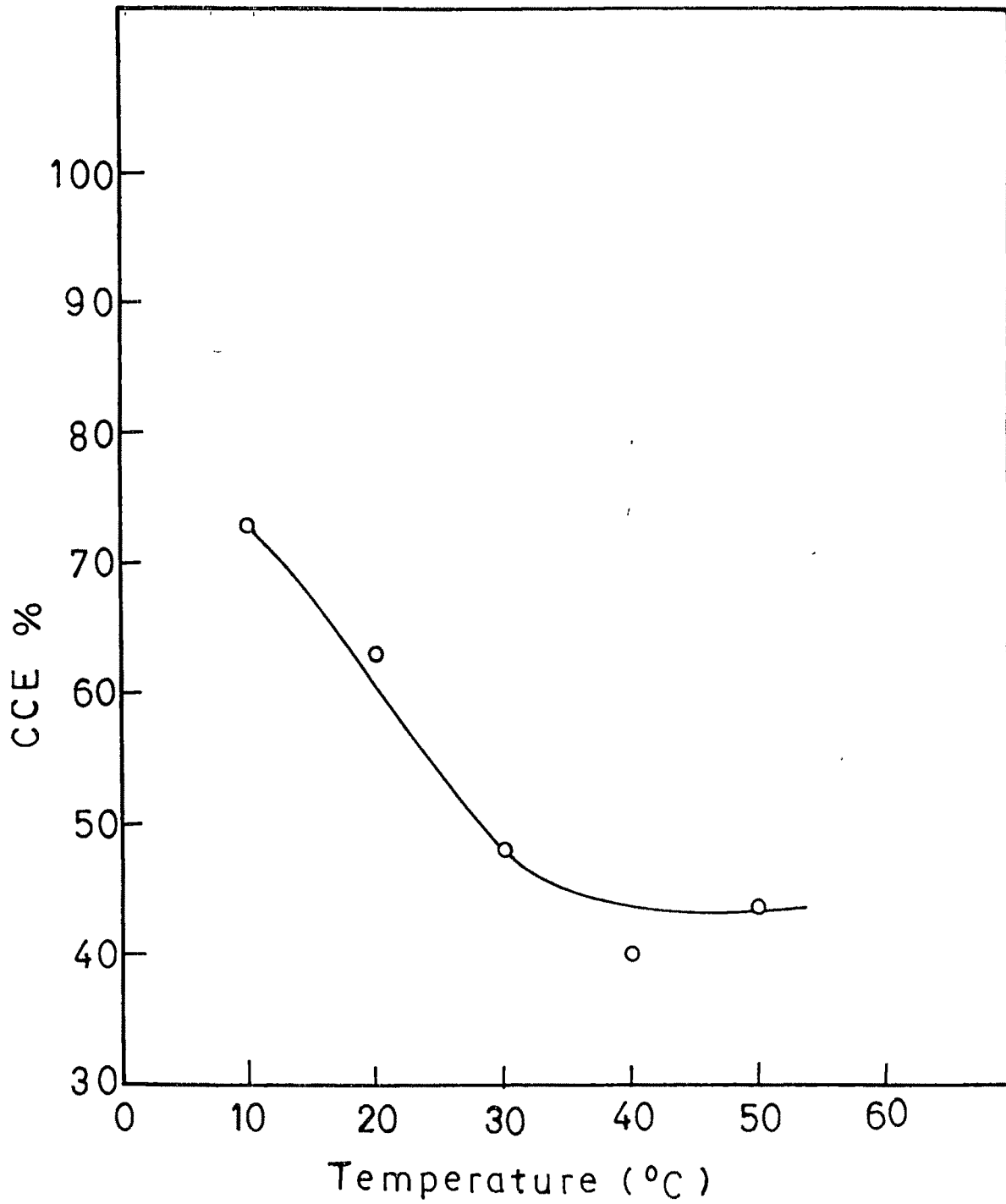


Fig. 5—Effect of temperature on cathode current efficiency (CCE %) of Zinc deposit.



TABLE 20.6 1- The effect of duration of electrolysis on the metal content and the percentage cathode current efficiency ( C.C. % ) of the zinc deposit.

Zinc sulphate : 10 gms. per 100 ml. Potassium thiocyanate : 10 gms. per 100 ml.  
 Boric acid : 2 gms. per 100 ml. Current density : 2.4 amp. per sq. dm.  
 Temperature : 30 C. Electrode distance : 4 cms.  
 Voltage : 2 volts.

Dr. No.	Duration of electrolysis mins.	Vt. of copper deposited in gm.	Vt. of zinc deposited in gm.	Percentage C.C.	Nature of deposit.
1	5	0.035	0.015	41.30 (40.0)	Smooth but slightly non-adherent.
2	10	0.036	0.015	49.15	
		0.083	0.060	67.66 (69)	Slight improvement.
		0.084	0.060	68.8	
* 3	15	0.097	0.087	86.42 (86)	Smooth and good. The colour of the bath solution is slightly pink.
		0.098	0.087	86.42	
4	20	0.139	0.113	83.76 (82)	Smooth and good deposit.
		0.134	0.114	81.97	
5	30	0.175	0.152	83.69 (84)	- do - blackish powder found to be adsorbed on the cathode.
		0.176	0.155	84.82	

\* Optimum condition.

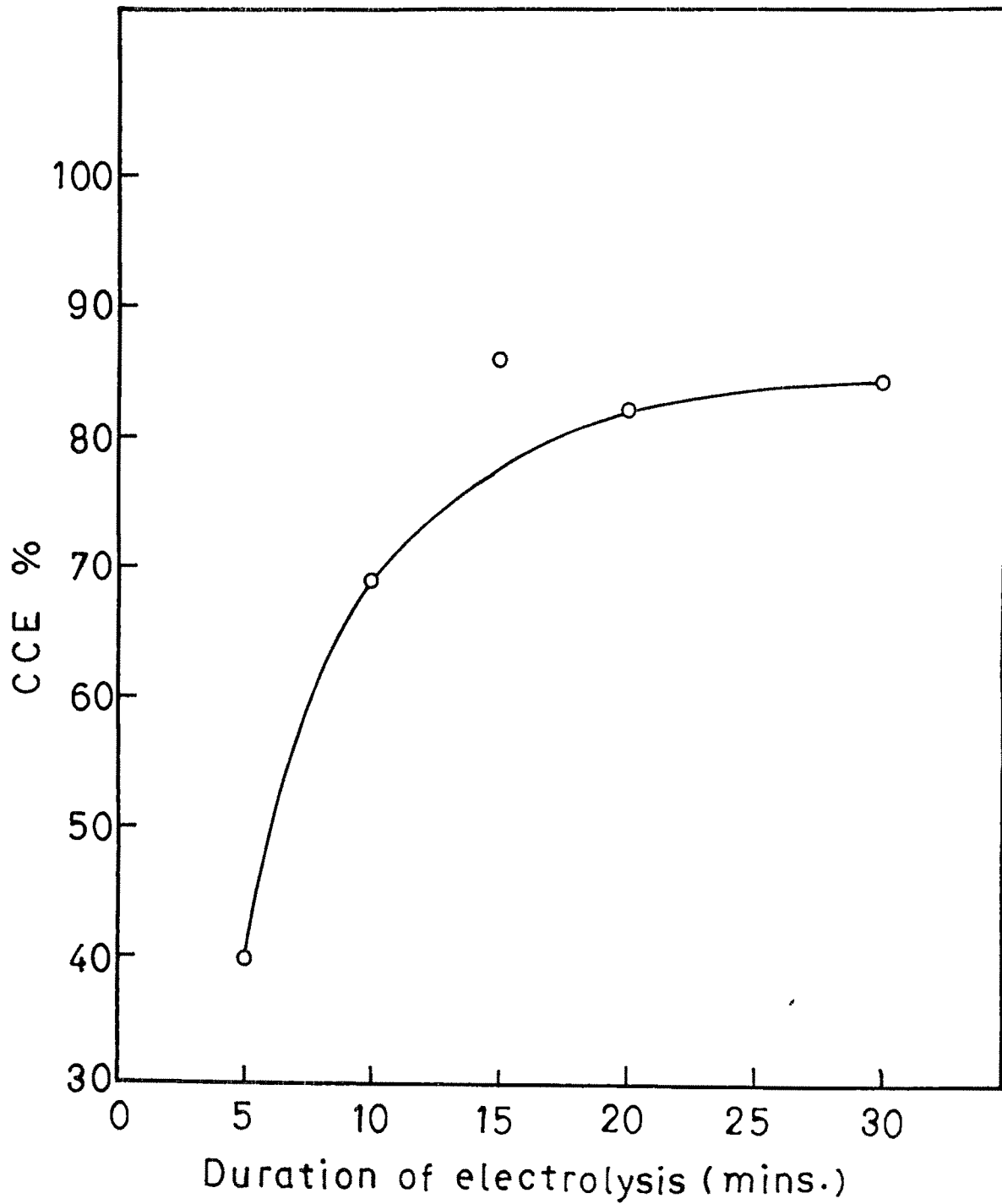


Fig. 6 — Effect of duration of electrolysis on cathode current efficiency (CCE %) of Zinc deposit .

TABLE NO. 7: The effect of electrolyte distance on the metal content and the percentage cathodic current efficiency (CCE %) of the zinc deposit.

Zinc sulphate : 20 gm. per 100 ml. Potassium chloride : 10 gm per 100 ml.  
 Nitric acid : 2 gm. per 100 ml. Current density : 2.4 amp. per sq. dm.  
 Temperature : 30°C. Voltage : 2 volts.

Gr. No.	Electrode distance cm.	Nt. of copper deposited coulometer gms.	Nt. of zinc deposited gms.	Percentage CCE	Nature of deposit.
1	1	0.052	0.053	52.28 (52.0)	Very smooth bright deposit.
2	+ 2	0.052	0.053	62.28	
3	3	0.053	0.049	56.38 (57.0)	Not significant change
4	* 4	0.053	0.050	59.04	
5	5	0.054	0.049	55.06 (55.0)	--do--
6	* 6	0.053	0.048	56.41	
7	7	0.050	0.047	56.61 (56.0)	--do--
8	8	0.050	0.047	55.51	
9	9	0.053	0.049	56.41 (56.0)	--do--
10	10	0.050	0.047	55.41	

\* Oxygen condition.  
 + cf plate 4.

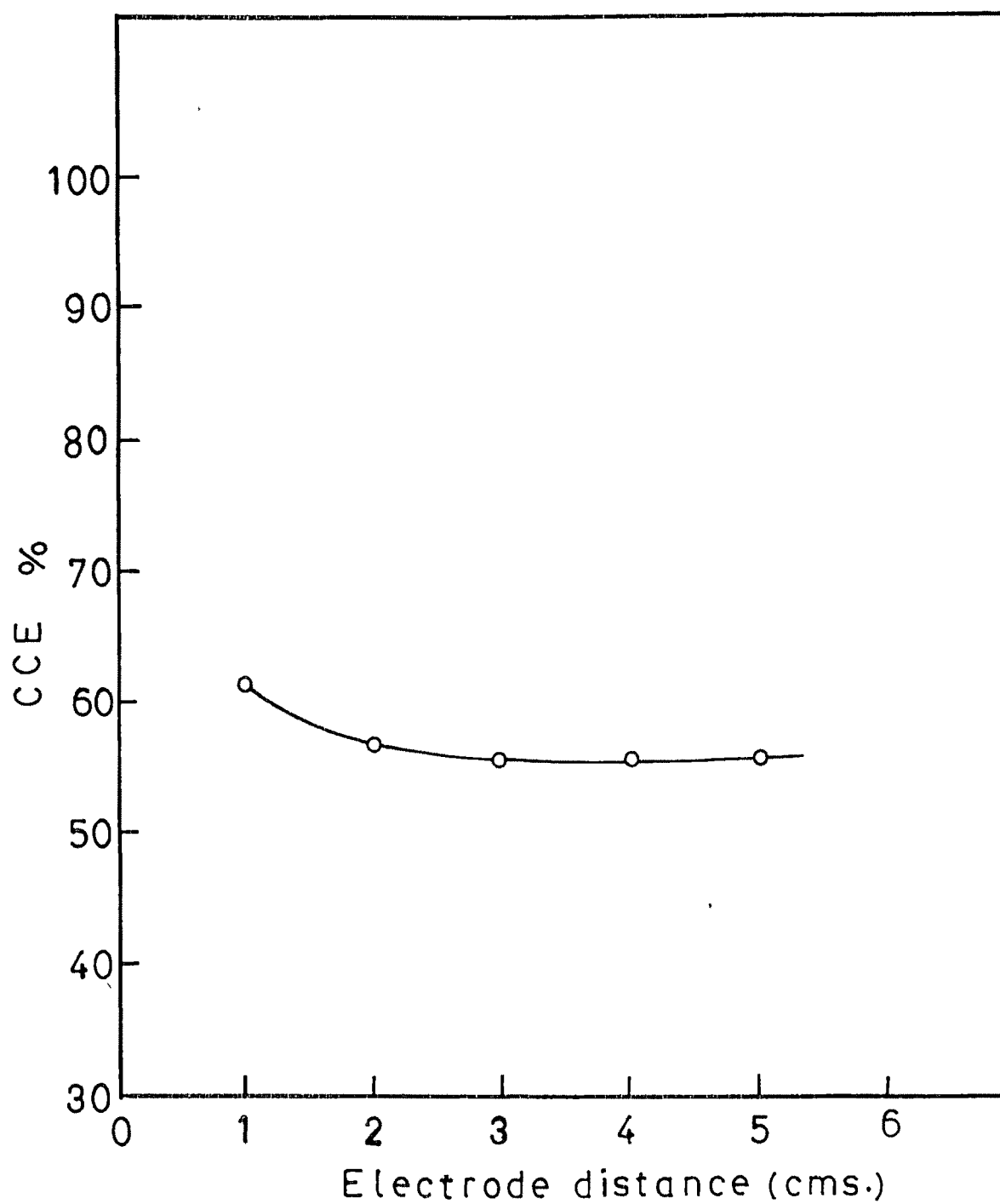


Fig. 7 — Effect of electrode distance on cathode current efficiency (CCE %) of Zinc deposit .

TABLE NO. 5 - The effect of addition agents on the metal content and the percentage cathode current efficiency (CCE %) of the zinc deposit.

Zinc sulphate + 10 gms. per 100 ml. Potassium thiocyanate + 10 gms. per 100 ml.  
 Serric acid + 2 gms. per 100 ml. Current density + 2.5 amp-per sq. dm.  
 Temperature + 30°C. Electrode distance + 4 cms.  
 Voltage + 2 volts.

Sr. No.	Addition Agent	Amount per 100 ml. gms.	wt. of copper deposited in gms.	wt. of zinc deposited	Percentage CCE	Texture of Deposit.
1	agar	0.3	0.050	0.020	35.54 (38.0)	Smooth bright uniform.
2	colatine	0.3	0.050	0.021	40.47 (40.0)	Not satisfactory.
3	Gum	0.3	0.053	0.022	39.99 (40.0)	Smooth
4	+ Glucose	0.3	0.057	0.024	40.57 (41.0)	Smooth bright. Very lustrous
5	Formaldehyde	√1 ml.	0.050	0.027	43.36 (42.0)	do -
	hyde		0.051	0.027	42.65	

+ cf Plate 5

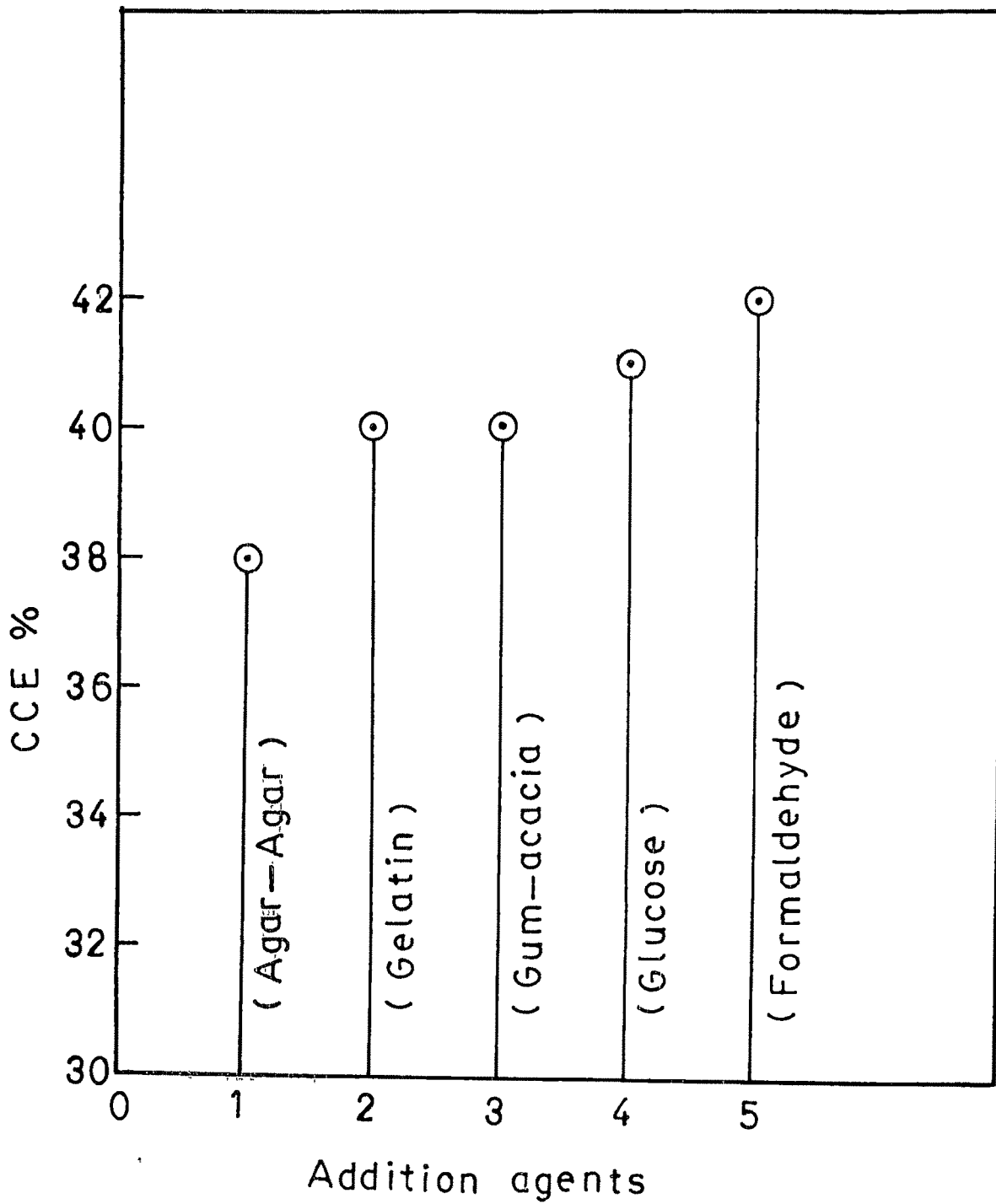
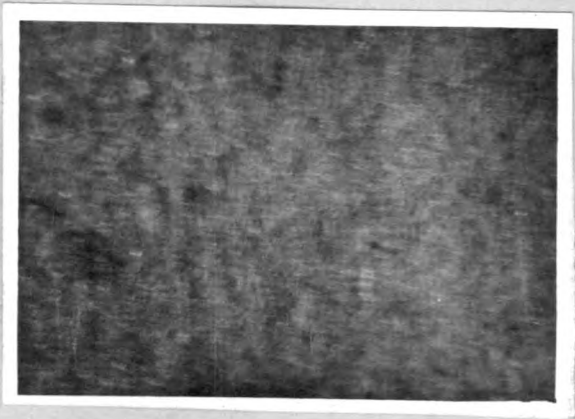


Fig. 8 — Effect of addition agents on cathode current efficiency (CCE %) of Zinc deposit .

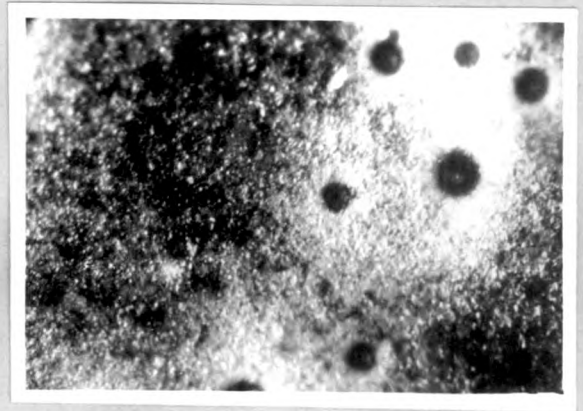
SUMMARYZinc System ( Optimum Conditions )

Table 8B: The influence of the physico-chemical factors upon the nature and magnitude of the zinc deposit has been shown in the previous Table Nos. 1 to 8 and in Figs 1 to 8. The ranges over which the parameters were studied and the optimum conditions arrived at by experiments are summarised below:

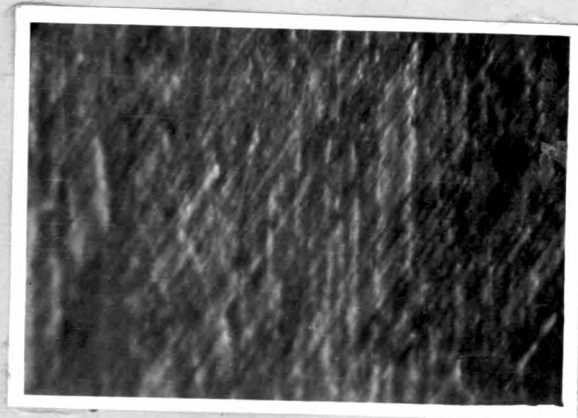
Parameters studied and Range	Optimum condition
1) Composition of the bath.	-
a) Concn. of zinc sulphate 5-40 gms per 100 ml. of the solution.	10 gms. per 100 ml. of the solution.
b) Concn. of Potassium thiocyanate 1-25 gms per 100 ml. of the solution.	10 gms. per 100 ml. of the solution.
c) Concn. of Boric acid 1-8 gms. per 100 ml of the solution.	2 gms. per 100 ml. of the solution.
2) Current density 0.8-4.0 amps. per sq. dm.	2.4 amps. per sq. dm.
3) Temperature 10 <sup>o</sup> -50 <sup>o</sup> C	30 <sup>o</sup> C.
4) Duration of electrolysis 5-30 minutes.	15 minutes.
5) Electrode distance 1-5 cms	4 cms.



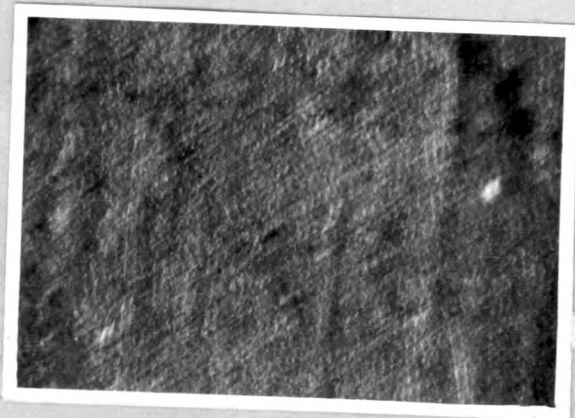
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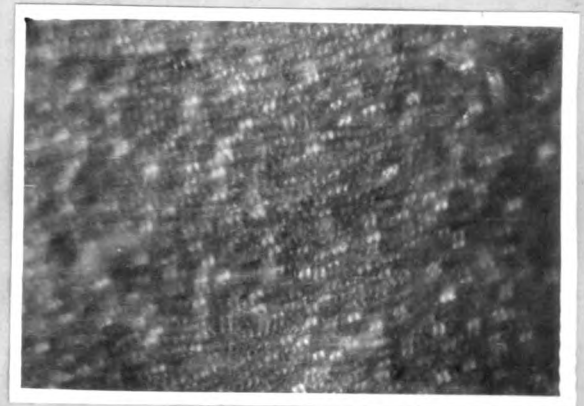
2



3



4



5

c.f. plate 1-5 (Zinc)

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### 3.3 Results and Discussion for Zinc : ( Table 1-3, Figs 1-3)

The plating variables had a marked effect on the quality and composition of the deposits and also on the CCE. The effects of different variables are explained below :

#### ELECTROLYTE CONCENTRATION :

#### 1) Effect of Zinc Sulphate Concentration : ( See Table -1, Fig-1 )

Effect of Zinc Sulphate concentration was studied between 5 gms. to 40 gms. per 100 ml. of the solution. Dull, spongy, non-adherent as well as smooth uniform and good deposits were obtained at different concentrations. At low concentration ( 5 gms. per 100 ml. ) as well as at high concentration dull, spongy, and black deposits were obtained. This indicates that neither low or high concentration of zinc sulphate was beneficial for good quality deposit. However, it was observed that concentration <sup>of</sup> zinc increased in the deposit with increase in the concentration of zinc sulphate. At the same time CCE was also increased with increase in the concentration of zinc sulphate and reached maximum at high concentration ( 40 gms. per 100 ml. ). The optimum condition for zinc sulphate concentration was 10 gms. per 100 ml. of zinc sulphate.

#### 2) Effect of potassium thiocyanate concentration (See table 2, Fig.2 ) :

Potassium thiocyanate was introduced to the bath as a solvent. The amount of potassium thiocyanate was varied from

1 gm to 25 gms. per 100 ml. For low concentration range the quality of deposit improved as there was increase in the concentration. However at high concentrations the blackening of the deposit occurs as time proceeds. Side by side tracing effect was also observed, particularly to the edges of the plate. The amount of zinc deposited remained mostly constant during the range. There was no marked effect as such on the CCE. The optimum condition was obtained at 10 gms. of potassium thiocyanate per 100 ml.

3) Effect of Boric acid concentration ( Cf. Table-3, Fig.3 ):

Boric acid has a marked effect on the nature of deposit and especially on CCE. With increase in the concentration of Boric acid, the CCE was found to increase, it reached maximum and then decreased with further increase in the concentration of Boric acid. At moderate concentration, the deposits were bright smooth and adherent. However at higher concentrations, the deposits were spongy and nonadherent. The optimum condition for Boric acid concentration was 2 gms. per 100 ml.

4) Effect of Current Density ( Cf. Table - 4, Fig - 4 ):

Using a bath of optimum composition, current densities varying from 0.6 to 4.0 A/cm<sup>2</sup> were studied. In the lower region of current density ( 0.6 A/cm<sup>2</sup> ), the deposits were dull, cloudy and patchy but with an increase in current density upto 2.4 A/cm<sup>2</sup> . Fine grained more shining and adherent deposits,

were obtained. Above this current density, the deposits turned black and showed burning effect (  $4.0 \text{ A/dm}^2$  ). This is always the case observed at high C.D. due to rapid depletion of the metal ions from the neighbourhood of the cathode. However, it was observed that with increase in the current density,  $\eta$  also increases. The optimum condition for current density was  $2.4 \text{ A/dm}^2$  , when the deposit obtained was bright and uniform.

5) Effect of Temperature : ( Cf Table - 5, Fig. 5 ) :

An increase in temperature in general, decreases the polarisation of the more noble metal relatively more than the polarisation of the less noble metal and causes an increase in the crystal size. The temperature range studied was  $10^\circ - 50^\circ \text{C}$  , under optimum conditions of bath composition, and C.D. At very low temperature the deposits obtained were not satisfactory, however by increasing the temperature, good deposits were obtained. The influence of temperature is caused by greater solubility and dissociation of the metal salt, which in turn, leads to a higher conductivity of the solution. A high temperature increases the solubility of the metal ions and decreases the viscosity of the solution. Another advantage of high temperature is that there is usually less absorption of hydrogen in the deposits and less stress and tendency towards cracking.

The deposits obtained at temperature greater than  $30^\circ \text{C}$  , were with black tinge. At very high temperature (  $50^\circ \text{C}$  ), still

and rough deposit was produced. Zinc content in the deposit and its CSE decreases proportionately with an increase in the temperature.

The optimum condition obtained for temperature was 30°C.

6) Effect of duration of electrolysis (cf Table 6 Fig - 6) :

Under optimum conditions, the period of electrolysis varied from 5-30 minutes. Zinc content in the deposit was increased from about 40 % to 84 % with increase of time from 5 minutes to 30 minutes. CSE also changed from 40 to 84%. Thus with increase in duration CSE increases upto 86 % and then nearly remains constant. At optimum condition i.e. 15 minutes, the deposit obtained was smooth and good. At longer times, the blackish powder found to be adsorbed on cathode. The optimum conditions was that of 15 minutes.

7) Effect of Variation of electrode distance (cf Table-7, Fig - 7) :

The electrode distance between anode and cathode was changed between 1.0 - 5 cms. It was noticed that the character of the deposit as well as the composition and CSE, was not affected. This is because whenever the anode and cathode are separated by such distances that the equipotential surfaces approach planes ( i.e. straight lines in the sectional drawings ), then any further increase in the spacing, has no appreciable effect upon the current distribution.

6) Effect of Addition agents ( Cf. Table - 6, Pg - 6 ):

It is well known that even small quantities of certain substances added to a depositing solution markedly influence the structure of the resulting deposit. These are called addition agents which can be well defined as substances which, while not necessary ingredients, are intentionally added to deposition baths in traces to produce a beneficial changes in the character of the deposit.

There is no fundamental principle underlying the use of these materials. But addition agents as a rule, exert the most favourable effect upon the deposit. Almost all addition agents are colloids. It had been thought that by adsorption in the deposit they may cause the metal to collect as very small crystals and cause a smooth deposit. The crystal growth at these points will be faster.

The addition agents listed in Table - 7, were introduced singly to the bath under optimum conditions and the effect was studied. Agar Agar, Gum, Glucose, Formaldehyde improved the character of deposit by promoting brightness. However, the deposits were not satisfactory in presence of gelatin. The stability was not affected by the use of the addition agents listed. The deposit, composition and CSE remained more or less the same.

### 3.4 Electrodeposition of Tin from Acid Chloride Bath :

Methods for the electrodeposition of tin, from either acid sulfate or alkaline solutions, have been known for more than 100 years. Forewood and Rogers ( 55) were granted a British patent on tin plating as early as 1843. Methods of tin deposition are summarized in two articles ( 56). In the acid baths the tin is present as stannous salt ( ex.  $\text{SnCl}_2$  ) while in alkaline baths it is present as stannic ( ex  $\text{Na}_2\text{SnO}_3$  ). The most important difference in these baths is the greater throwing power of the alkaline stannate baths, however the acid bath has the advantage that the valence of tin in it is II, compared with IV in the stannate bath, hence twice as much tin is deposited, at 100 percent efficiency, per ampere-hour in the acid as in the alkaline bath. The cathode efficiency is usually 95 % in acid bath and may be only 75 % in alkaline bath. The conductivity of the acid bath is higher than that of alkaline.

The substitution of tin plating for hot dipping of sheet steel for use in canning industry ( 57) came about through the wartime. Tin is not normally protective to steel, but in the particular conditions obtaining inside the sanitary can (sanitary meaning containing foods, or beverages ) the usual potentials of tin and iron are reversed and tin becomes protective. Tin plating of steel for use in the 'tin can' is the largest single use of electroplating in terms of tonnage of products.

Tin plating electrolytes in acid baths, usually the sulphate and the chloride, fluoride electrolytes, commercially

known as the "Ferrotan" and "Halogen" processes, respectively, have achieved worldwide acceptance by the electroplate producers (58). Although tin may be deposited from many of the soluble acid tin salts, only three types of tin solutions stannous sulphate, stannous fluoborate and halogen formulations are in common use.

In 1942 the Grasseville post organization, in response to request from Weirton steel company, evaluated the stability of various tin plating solutions leading to the development of "Halogen Tin" process. The process was based on a solution of stannous chloride, plus alkali metal chlorides and fluorides with suitable addition agents, patents issued to Schweikher, Hoffmann and Gray et al formed the original basis for the "Halogen Tin" process. A review by Du Rose of the early developments of the process indicates that the transition from pilot plant to full scale production at a speed of 325 m / min was achieved in one year. Much credit goes to Grasseville research team and the Weirton steel company (60).

It is the objective of the present investigation to offer a simple acid bath (acid - chloride) in preference to the other acid or alkaline baths reported earlier (55-60), giving good quality deposit with a high CE (over 90%) even on copper, iron and other base metals. The bath is easy to handle, and gives good reproducibility of results.

### 3.4.1 Earlier work on Electrodeposition of Tin :

Number of methods for the electrodeposition of tin from different baths have been known for more than 100 years. Mathers and co-workers ( 61 ) tested many of these early baths and found none satisfactory. Forester ( 62 ) hinted at the reason. All were based on sodium stannite formed from a stannous salt in the presence of excess alkali.

Proctor ( 63 ) and Fraize were apparently the first to publish a plating bath based on sodium stannate. As far as acidic baths for tin plating are concerned, number of investigations were involved in solving the problem with the additives which they found were necessary to give smooth and adherent deposit. (64).

Research on tin electrodeposition continued at a rapid pace after 1960. Numerous articles and patents have appeared in the literature describing new addition agents, brighteners, crystal structure, effect of temperature, throwing power etc. (65 to 70).



TABLE NO. 9 i- The effect of concentration of the tin chloride on the metal content and the percentage cathode current efficiency ( 100 g ) of tin deposit.

Hydrochloric acid : 1.2 N in mixture. Sodium chloride : 2 gms per 100 ml.  
 Current density : 0.42amps per sq. cm. Temperature : 27°C.  
 Duration of electrolysis : 30 minutes Electrode distance : 4 cms.  
 Voltage : 1 Volt.

Obs. No.	Concn. of tin chloride per 100 ml. gms.	% of copper deposited in coulometer gms	wt. of tin deposited gms	Eff %	(Mean)	Nature of deposit
1	2	0.032	0.052	56.75	(86)	White, adherent with little flake formation.
2	3	0.032	0.051	55.53	(89)	Fine adherent with no flake formation.
3	4	0.029	0.050	91.50	(92)	-03- Slight improvement shining and satisfactory.
4	5	0.030	0.053	93.57	(93)	White, adherent.

\* Optimum condition.



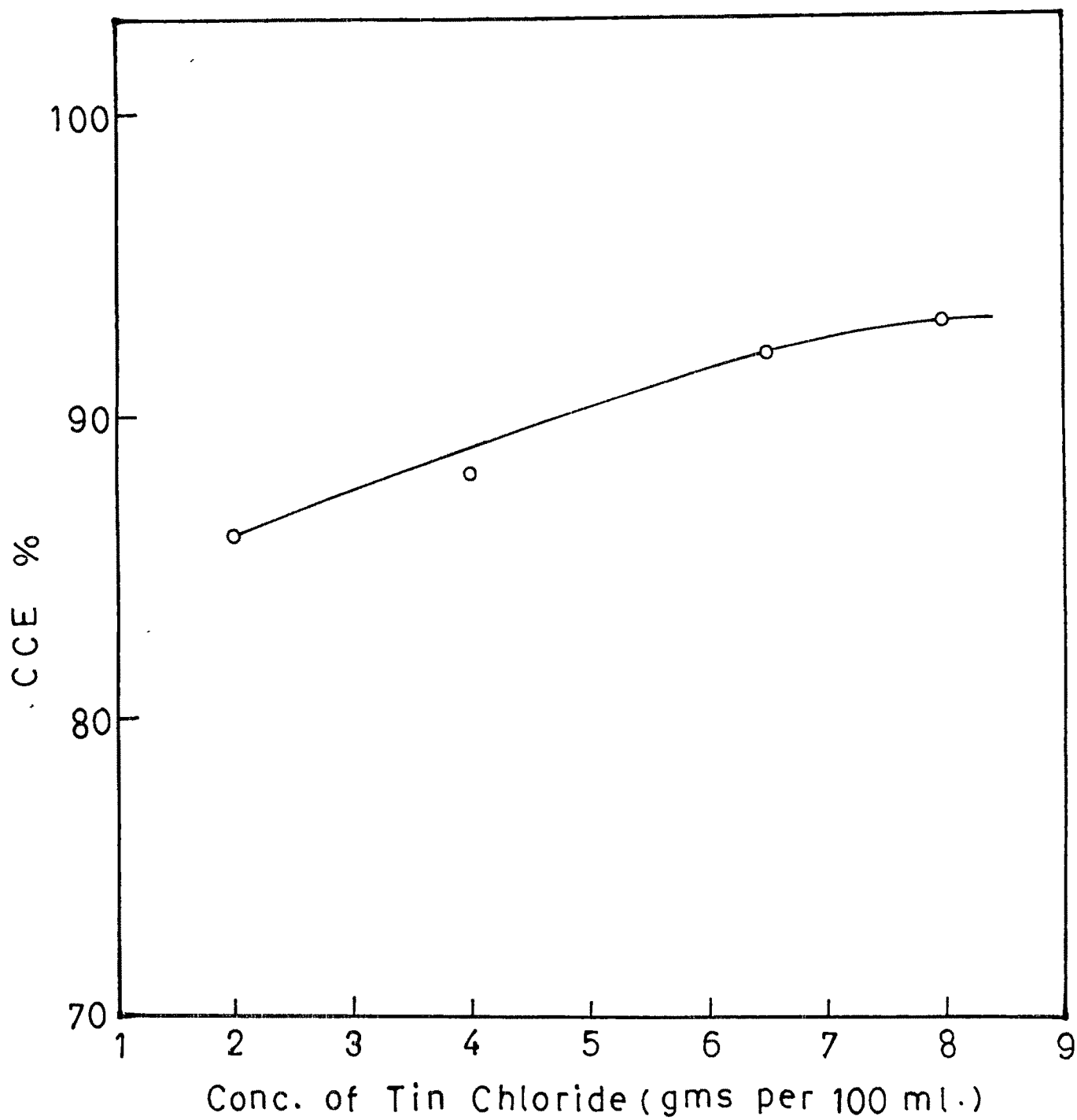


Fig.9 —Effect of Tin Chloride concentration on cathode current efficiency (CCE % ) of Tin deposit .

TABLE 10.10 :- The effect of concentration of hydrochloric acid on the metal content and the percentage cathode current efficiency ( C.E. % ) of tin deposit.

Tin chloride : 4 gms. per 100 ml. Sodium chloride : 2 gms. per 100 ml.  
 Current density : 0.42amps per sq. cm. Temperature : 20°C.  
 Duration of electrolysis : 30 minutes. Electrode distance : 4 cms.  
 Voltage : 1 Volt.

Sl. No.	Concn. of hydrochloric acid, Normality in mixture g.	Wt. of copper deposited in coulometer gms.	Wt. of tin deposited Gms.	C.E. % (Mean)	Nature of deposit.
1	0.4	0.032	0.061	100.1 (91)	Uniform, adherent and thick. The solution turns greenish yellow after some time.
2	0.6	0.029	0.050	94.76 (95)	" " " "
3	0.8	0.029	0.049	94.75 (93)	Fine adherent, uniform shining.
4	1.2	0.030	0.051	93.22 (92)	Fine, adherent little tree formation.
5	1.6	0.032	0.049	92.9 (93)	Adherent, evolution of gas at cathode.
		0.032	0.049	92.6	

\* Optimum condition.

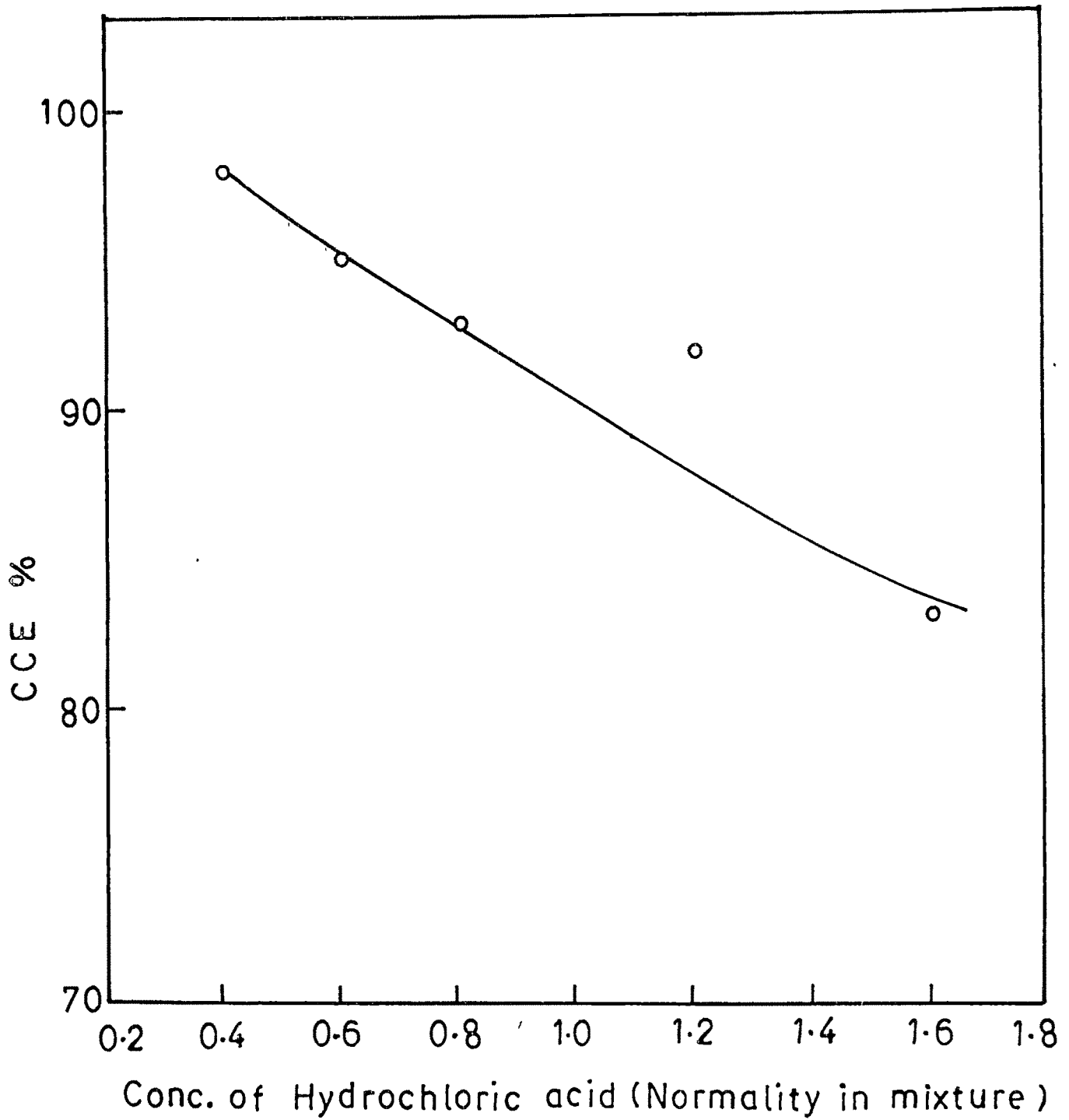


Fig. 10 —Effect of Hydrochloric acid concentration on cathode current efficiency(CCE %) of Tin deposit .

TABLE No. 11 :- The effect of concentration of sodium chloride on the metal content and the percentage cathode current efficiency ( C.A.E. ) of tin deposit.

Tin chloride : 4 gms. per 100 ml. Hydrochloric acid : 0.2 G in mixture.  
 Current density : 0.42 amps per sq. cm. Temperature : 20°C.  
 Duration of electrolysis : 30 minutes. Electrode distance : 4 cms.  
 Voltage : 1 volt.

Obs. No.	Concn. of sodium chloride per 100 ml. gms.	Nt. of copper deposited in coulometer gms.	Nt. of tin deposited gms.	C.A.E. % (Mean)	Nature of deposit.
1	2	0.027	0.049	96.31 (95)	Fine adherent and uniform.
2	3	"	"	"	" (89)
3	4	0.029	0.049	89.67 (91)	More silvery and lustrous than previous
4	5	0.031	0.054	92.46 (90)	-do- Slight tree formation tendency.
5	6	0.028	0.049	92.67 (89)	Evolution of gas. Not satisfactory.
		0.031	0.051	87.31	

\* Optimum condition.

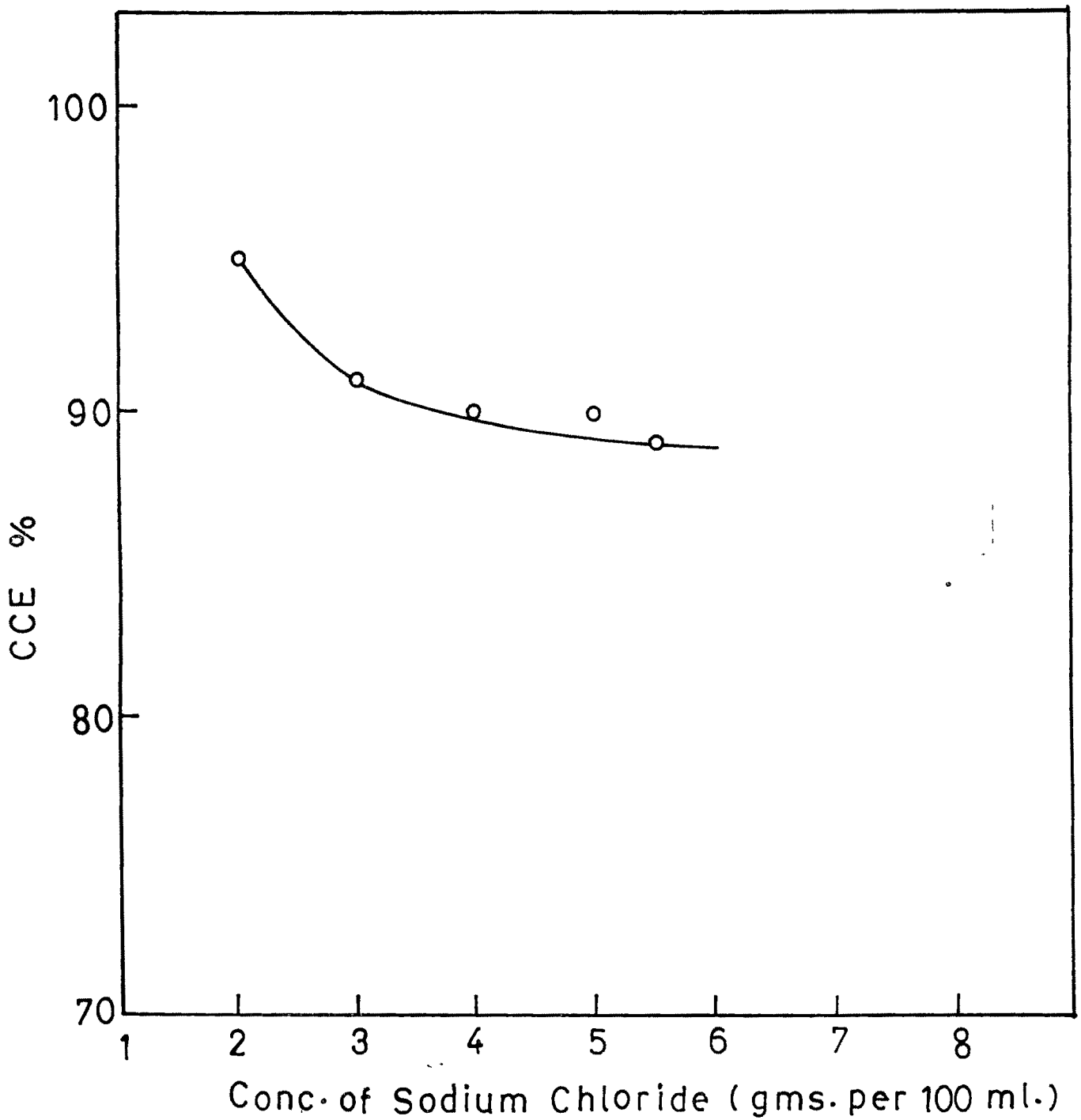


Fig. 11 — Effect of Sodium Chloride concentration on cathode current efficiency (CCE %) of Tin deposit.

TABLE NO. 12 - The effect of current density on the metal content and the percentage cathode current efficiency (220 K) of tin deposit.

Tin chloride : 4 gms per 100 ml. Hydrochloric acid : 0.0 N in mixture.  
 Sodium chloride : 4 gms. per 100 ml. Temperature: 25°C.  
 Duration of electrolysis : 30 minutes. Electrode distance : 4 cms.  
 Voltage : 1 to 3 Volts.

Chg. No.	Current density amp. per sq. cm.	Wt. of Copper deposited in amp. hour	Wt. of tin deposited gms.	Eff. %	(Mean)	Nature of deposit.
1	0.084	-	-	-	-	Tin adherent unsatisfactory.
2	0.25	0.015	0.022	77.04	(78)	Adherent and dull.
3	0.42	0.016	0.023	77.34	-	Adherent, bright and fine.
4	0.63	0.025	0.044	89.32	(87)	-
		0.039	0.047	81.14	-	-
5	0.94	0.049	0.082	90.66	(91)	-
		0.040	0.092	90.66	-	-
6	1.04	0.050	0.086	91.29	(91)	Tin formation tendency increases.
		0.050	0.086	91.29	-	Tin adherent, not satisfactory.

\* Optimum condition.  
 + cf Plate 6.

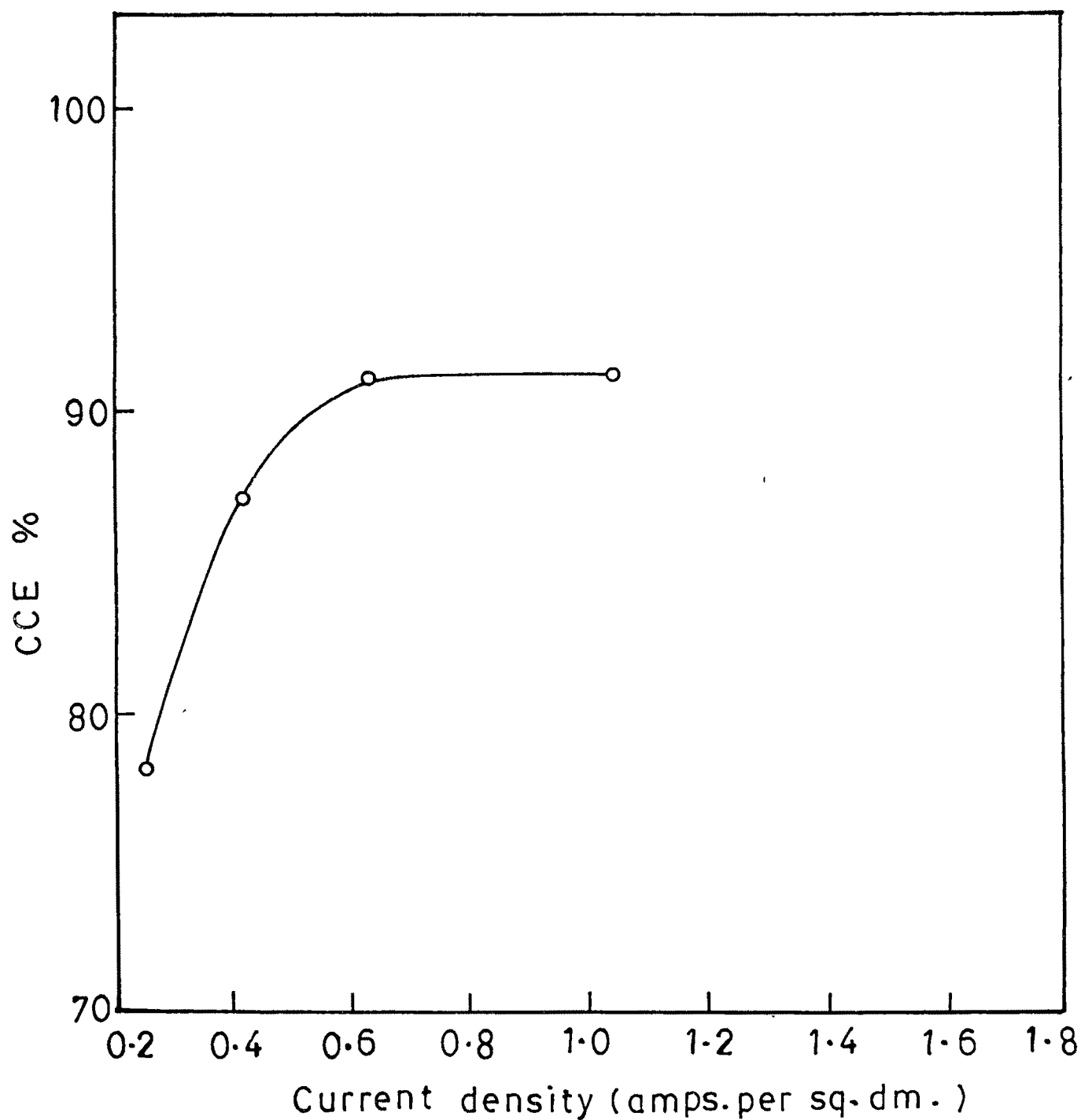


Fig.12 — Effect of current density on cathode current efficiency (CCE %) of Tin deposit .



TABLE NO. 13 - The effect of temperature on the metal content and the percentage cathode current efficiency (CCE %) of tin deposit.

Sin chloride : 4 gm. per 100 ml. Hydrochloric acid : 0.8 M in sixtara  
 Sodium chloride : 4 gm. per 100 ml. Current density : 0.42 amp. per sq. dm.  
 Duration of electrolysis: 30 minutes. Electrode distance : 4 cms.  
 Voltage : 1 Volt.

Obs. No.	Temperature °C	Wt. of copper deposited in coulometer (gm.)	Wt. of tin deposited (gm.)	CCE % (Mean)	Nature of deposit.
1	10	0.030	0.058	97.30 (97)	Non-adherent, white.
2	20	0.030	0.055	97.30	
3	* 30	0.030	0.054	95.92 (96)	Adherent, bright.
		0.029	0.053	96.99	
4	40	0.029	0.049	97.84 (88)	Very fine, adherent, bright.
		0.030	0.050	98.45	
5	40	0.029	0.039	65.86 (67)	Adherent, nonuniform, bright.
		0.027	0.035	69.79	
6	+ 50	0.026	0.019	36.74 (36)	Dull, adherent, evolution of gas.
		0.027	0.018	35.93	

\* Optimum condition. + cf Plate 7.

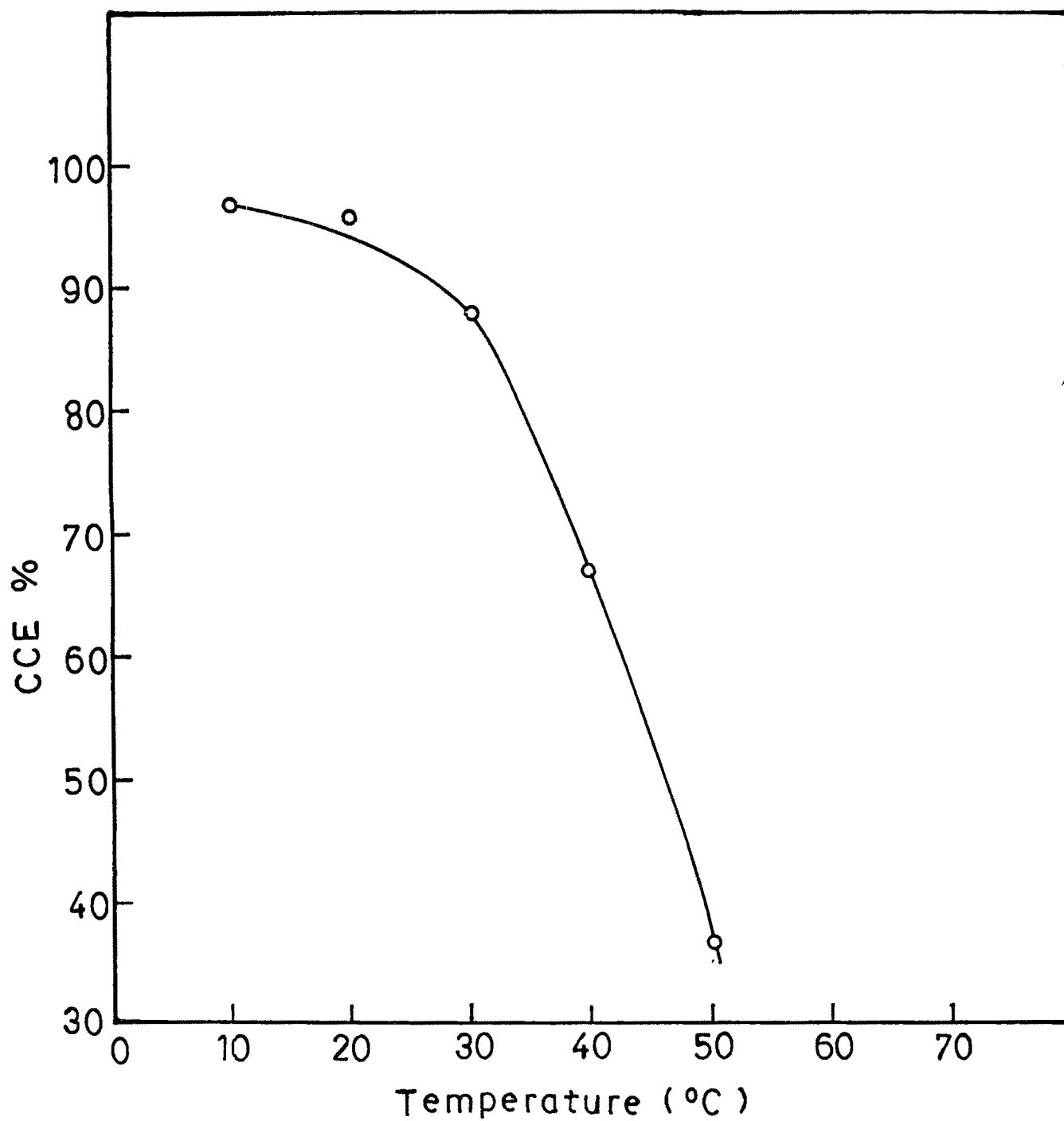


Fig. 13 – Effect of temperature on cathode current efficiency (CCE %) of Tin deposit .

TABLE No. 14: The effect of duration of electrolysis on the metal content and the percentage cathode current efficiency (7%  $\pm$ ) of tin deposit.

Tin chloride : 4 gm. per 100 ml. Hydrochloric acid : 0.8 M. in mixture.  
Sodium chloride : 4 gm. per 100 ml. Current density : 0.42 amp. per sq. dm.  
Temperature : 30°C. Electrode distance : 4 cm.  
Voltage : 1 Volt.

No.	Duration of electrolysis in minutes.	wt. of copper deposited in gm.	wt. of tin deposited in gm.	Gas % (norm)	Nature of deposit.
1	10	0.009	0.017	100 (100)	Nonuniform but adherent.
2	20	0.009	0.017	100	Uniform, smooth bright, adherent.
3	30	0.015	0.030	99.51 (99)	Very fine, adherent, bright.
4	40	0.015	0.035	99.06	
5	50	0.029	0.049	99.67 (99)	
6	60	0.030	0.050	99.65	
7	70	0.040	0.064	94.91 (95)	Little tree formation tendency.
8	80	0.040	0.065	96.24	tree formation tendency increases.

\* Optimum condition. + c.f. Plate 8.

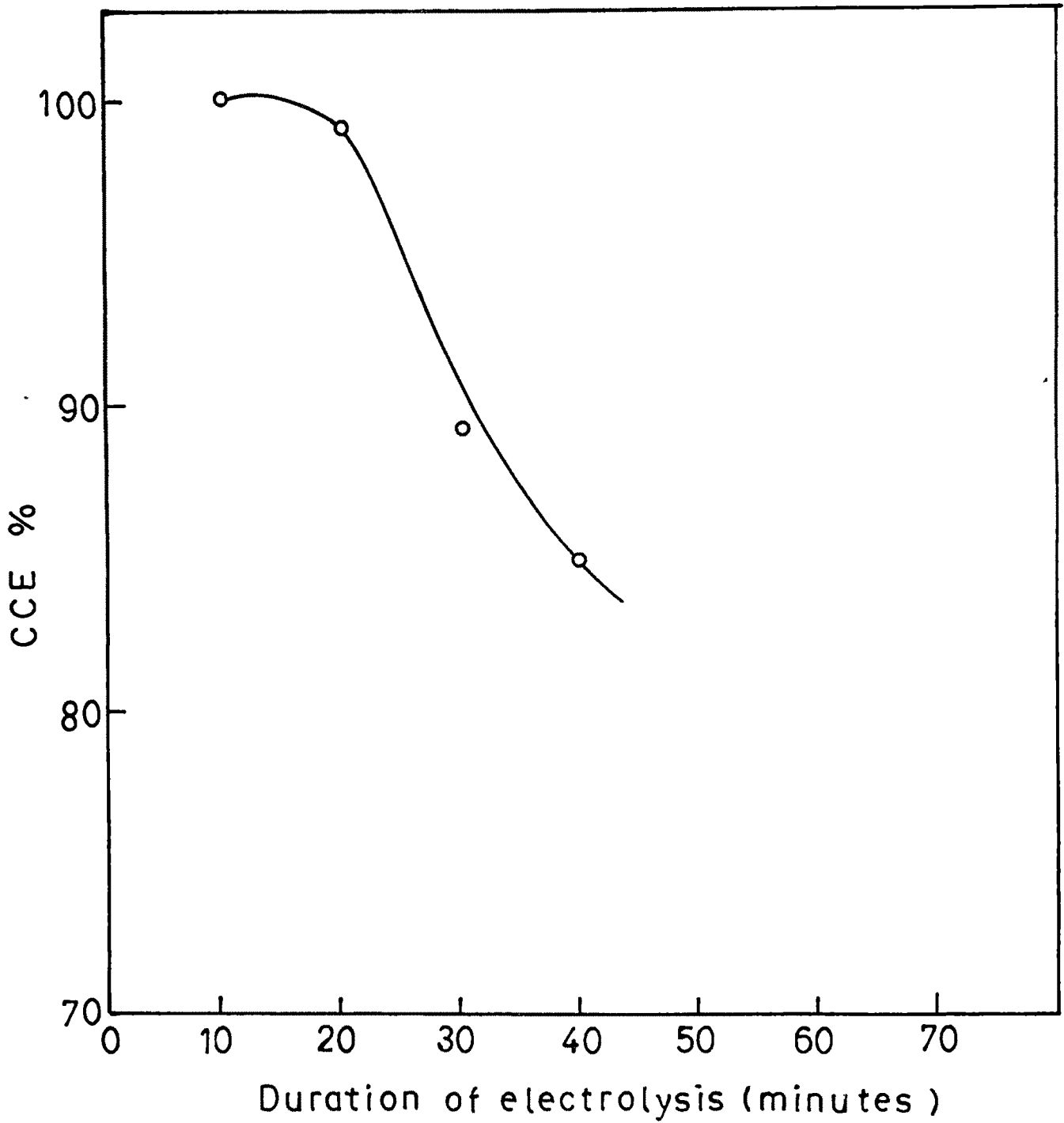


Fig. 14 —Effect of duration of electrolysis on cathode current efficiency (CCE %) of Tin deposit .

TABLE NO. 15 :- The effect of electrode distance on the metal content and the percentage cathode current efficiency (CCE %) of tin deposit.

Tin chloride: 4 gms. per 100 ml. Hydrochloric acid: 0.0 N in mixture.  
 Sodium chloride: 4 gms per 100 ml. Current density: 0.42 amps. per sq. dm.  
 Temperature: 30°C Duration of electrolysis: 30 minutes.  
 Voltage: 1 Volt.

Obs. No.	Electrode distance deposited in cm.	Wt. of copper deposited in coulometer gms.	Wt. of tin deposited gms.	CCE % (Mean)	Nature of deposit.
1	2	0.026	0.043	87.78 (87)	Bright fine.
2	4	0.032	0.051	54.50	Bright fine with silvery spinning.
3	6	0.029	0.049	89.67 (89)	"
4	8	0.031	0.050	85.60	"
5	10	0.030	0.049	86.68 (87)	"
6	12	0.030	0.049	86.68 (87)	"
7	14	0.030	0.049	86.68 (87)	"
8	16	0.030	0.049	86.68 (87)	"
9	18	0.030	0.049	86.68 (87)	"
10	20	0.030	0.049	86.68 (87)	"

\* Optimum condition. + cf. Plate 9.

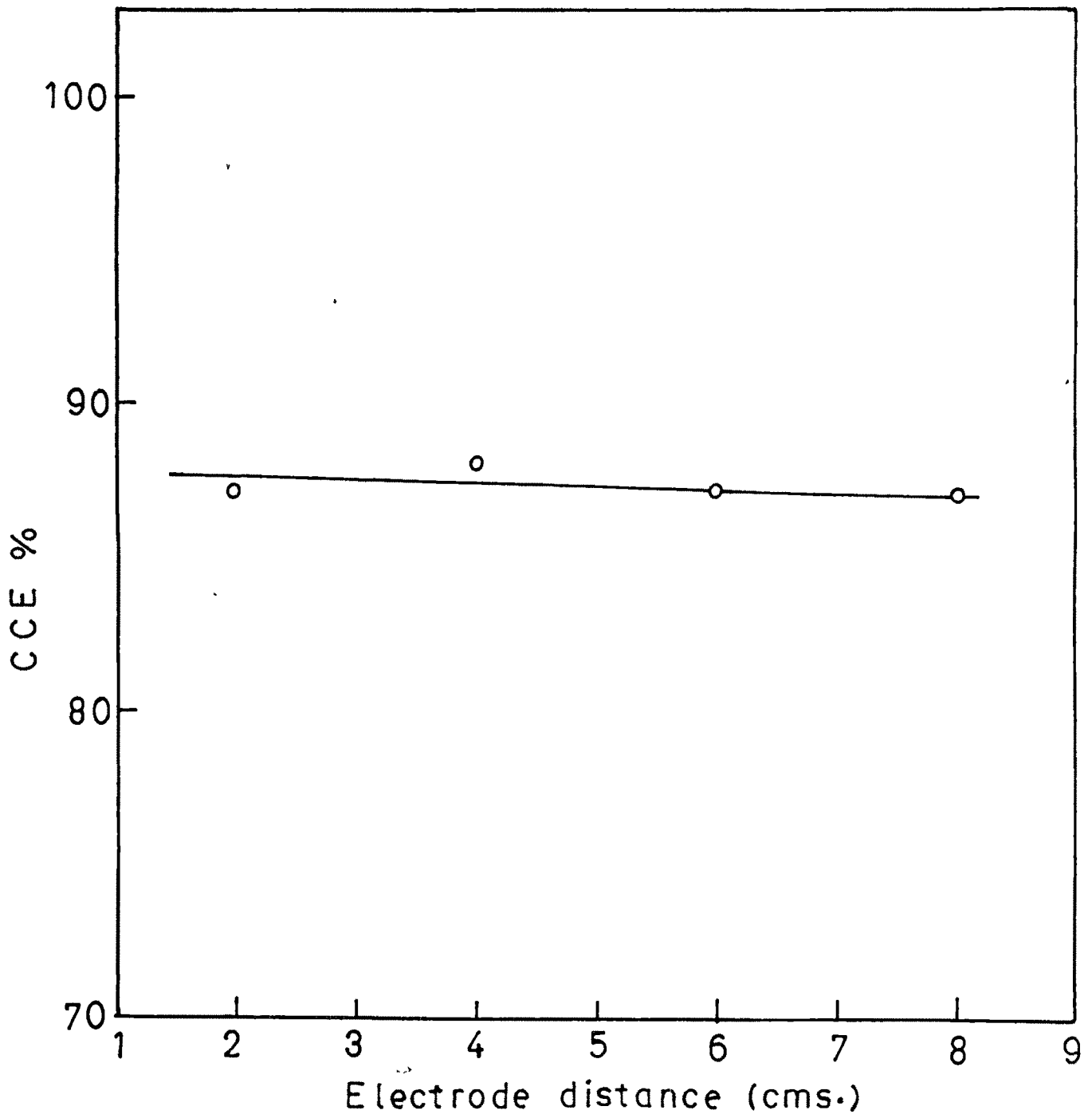


Fig. 15 — Effect of electrode distance on cathode current efficiency (CCE %) of Tin deposit.

TABLE 10.16 -- The effect of addition agents on the metal content and the percentage cathode current efficiency (see II) of tin deposit.

Tin chloride : 4 gms. per 100 ml. Hydrochloric acid : 0.8 N in mixture  
 Sodium chloride : 4 gms. per 100 ml. Current density : 0.42 amp. per Sq. Cm.  
 Temperature : 30°C. Duration of electrolysis : 30 minutes.  
 Electrode distance : 4 cms. Voltage : 1 Volt.

Add. Agent No.	Addition agent per 100 ml.	wt. of copper deposited in 100 ml.	gms.	wt. of tin deposited	gms.	C.C.E. %	Nature of deposit.
1	Glucose	0.3 gms.	0.024	0.043	95.08	(96)	Good, but considerable tree formation.
2	Sugar	0.3 gms.	0.025	0.046	93.40	(96)	Good, tree formation tendency less than previous.
3	Carbon disulphide	.1 ml.	-	-	-	-	Black, non-adherent.
4	1-phenyl-2-pyridyl powder.	0.3 gms.	0.027	0.047	92.38	(92)	Very fine, bright, lustrous and uniform. No tree formation at all.
5	Gelatin	0.3 gms.	0.025	0.045	95.53	(97)	Adherent, bright, fine and uniform. No tree formation.
6	Quin Acetic	3.3 gms.	0.025	0.040	93.89	(92)	- do -
7	Resorcin	.1 ml.	0.025	0.044	95.51	(97)	Fine grained, bright, very slight tree formation at edges.
			0.025	0.046	97.65	(97)	

cf. Plate 10.

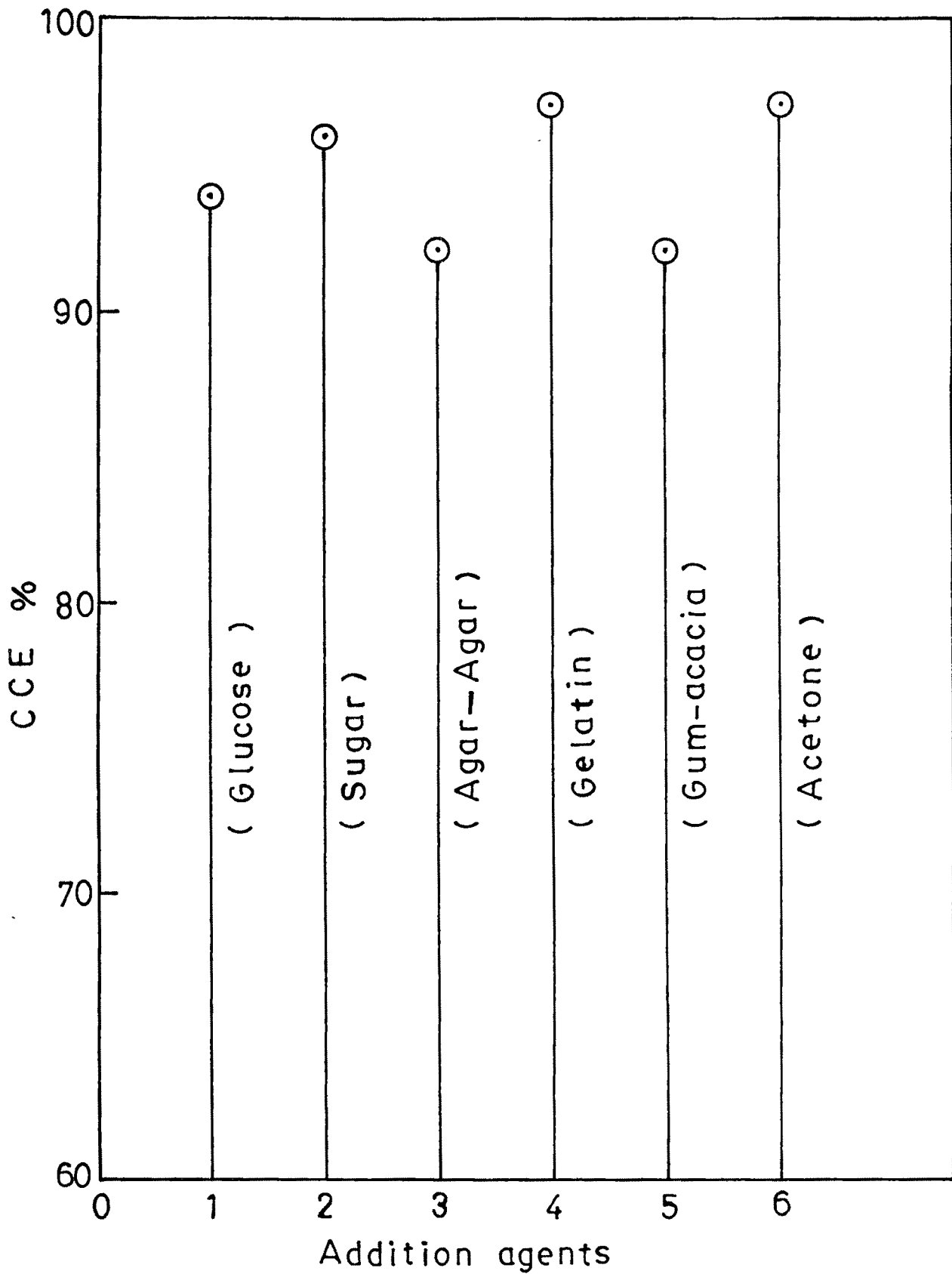


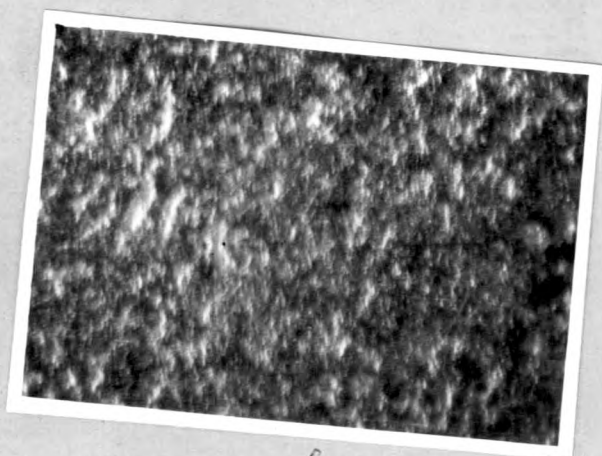
Fig. 16 — Effect of addition agents on cathode current efficiency (CCE %) of Tin deposit .



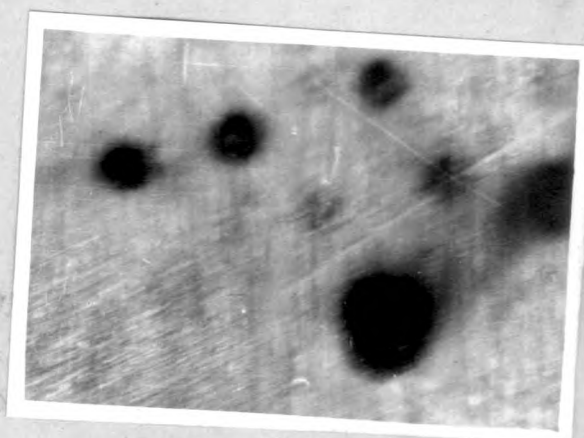
SUMMARYTIN SYSTEM (OPTIMUM CONDITIONS)

Table 16-A : The influence of the Physico-chemical factors, upon the nature and magnitude of the tin deposit has been shown in the previous Table Nos. 9 to 16 and graphically in Figs. 9 to 16. The ranges over which parameters were and optimum conditions arrived at by experiments, are summarized below:

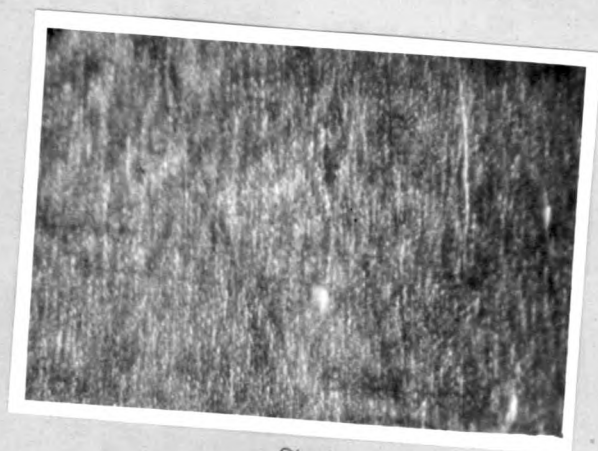
Parameter studied and Range	Optimum condition
1) Composition of the bath	-
a) Concn. of tin chloride 2-8 gms. per 100 ml of the solution.	4 gms. per 100 ml of the solution.
b) Concn. of hydrochloric acid 0.4 to 1.6 Normal (Normality in mixture).	0.8 N (Normality in mixture).
c) Concn. of sodium chloride 2 to 6 gms per 100 ml of the solution.	4 gms. per 100 ml of the solution.
2) Current density 0.084 - 1.04 amps per sq. dm.	0.42 amps. per sq. dm.
3) Temperature 10°-50°C	30°C.
4) Duration of Electrolysis 10-50 minutes.	30 minutes.
5) Electrode distance 2 - 10 cms.	4 cms.



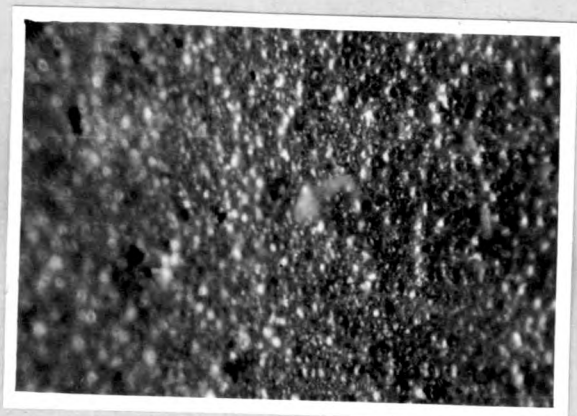
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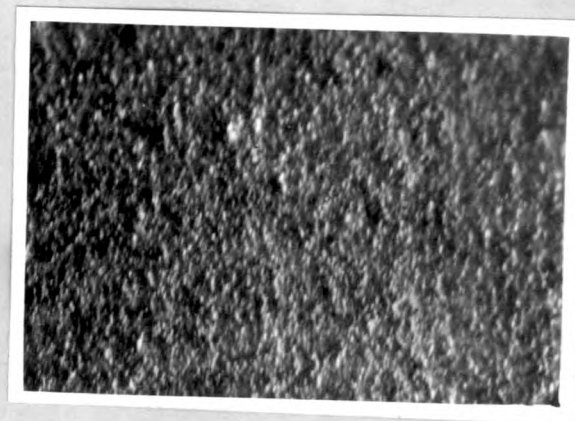
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8



9



10

cf. plate 6-10 (Tin)

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### 3.5 Results and discussion (Table 9-16, Figs 9-16) for Tin :

The influence of different parameters on composition of the deposit, cathode current efficiency (CCE), structure and appearance of the deposits have been detailed below :

#### EFFECT OF ELECTROLYTE CONCENTRATION :

##### 1) Effect of tin chloride concentration ( Cf Table-9, Fig-9) :

The composition of tin chloride in the bath was varied from 2 to 8 gms per 100 ml in the bath. It was found that increase in the conc. of tin chloride in the bath improved the quality of the deposit. At low concentration, creasing effect was observed, but as concentration was increased, no creasing was seen. There was also an increase in the CCE with increase in the concentration of tin chloride, however, the amount of tin deposited nearly remained constant. Fine adherent and shining deposits were obtained at 4 gms. of tin chloride per 100 ml of solution.

##### 2) Effect of hydrochloric acid concentration ( Cf. Table-10, Fig - 10 ) :

The bath used for tin deposition was hydrochloric acid bath. The acid bath has the advantage that the valence of tin in it is II compared with IV in the stannate bath; hence twice as tin is deposited, at 100 % efficiency per ampere-hour in the acid as in the alkaline bath. The cathode efficiency is usually about 95 percent in the acid bath and may be only 75 %

in the alkaline bath. This was actually the case observed. The CSD observed was above 95 % in general. From Table - 10, it was observed that, at 0.8 N concentration of hydrochloric acid, the deposits obtained were fine, adherent and shining. However, at higher concentrations, there was evolution of hydrogen gas near cathode.

3) Effect of sodium chloride concentration ( Cf Table-11,

Fig - 11.1 :

Concentration of sodium chloride was changed between 2-5 gms per 100 ml. The quality and nature of the deposit was found to be improved with increasing concentration of sodium chloride and lustrous, smooth, uniform and adherent deposits were obtained at 4 gms. per 100 ml. This might be probably due to increased conductivity of the bath. The composition and CSD of the metal content were found to decrease with increase in the concentration of sodium chloride. At higher concentrations the deposits were not satisfactory due to evolution of hydrogen.

4) Effect of current density ( Cf Table 12 Fig - 12 ) :

Current densities ranging from 0.084 - 1.06 amps per Sq. cm. were used. At low C.D. the deposits were nonadherent and unsatisfactory. The quality of deposits improved as C.D. was increased upto 0.42 amps. per Sq.cm. At 0.42 amps per sq.cm., the deposits obtained were quite satisfactory, but further increase of C.D. resulted in increase in the tree formation tendency. At high C.D. nonadherent deposits were obtained.

with increase in K.F., tin content and G.S. of the deposit were increased to a great extent.

5) Effect of temperature ( Cf Table 13, Fig - 13 ) :

The temperature range studied was  $10^{\circ} - 50^{\circ}\text{C}$ , under optimum condition of bath composition and C.S. The tin content in the deposit decreased with increase in temperature. The quality of the deposits was found to be satisfactory at  $30^{\circ}\text{C}$ . (Optimum condition ), but beyond this temperature no improvement was observed. At higher temperature (  $50^{\circ}\text{C}$  ) it became inferior.

6) Effect of duration of electrolysis ( Cf Table -14, Fig-14):

Electrolysis was carried out for 10-15 minutes under otherwise optimum condition. Change in the deposit composition was not appreciable with respect to the duration of electrolysis. The G.S. decreased steadily. The deposits were bright uniform, and adherent at 30 minutes ( optimum condition. ), but little tree formation tendency was observed, as duration of electrolysis was increased to more than 30 minutes.

7) Effect of electrode distance ( Cf Table -15, Fig.15):

The distance between anode and cathode was changed between 2-10 cms. It was noticed that the character of the deposit as well as the composition and G.S., were not affected.

8) Effect of addition agents ( Cf Table 16, Fig - 16) :

A number of addition agents were added separately and singly to the bath under optimum conditions and the results are summarized in Table - 16. It was found that brighter and smoother

deposits were obtained in presence of Agar Agar powder, Gelatine and Gum-Arabica. For glucose, sugar and acetone there observed the tree formation tendency, although the quality of deposits was good. However for carbon di-sulphide the deposits obtained were black and nonadherent.

### 3.6 Role of Complexes in Electrodeposition of Zinc and Tin :

It is worth while to discuss the fine character of the deposit on the basis of complexes that are believed to be formed in the respective baths, selected for Zn and Sn deposition. The deposition of metals, according to Cress<sup>1</sup>, is a crystal growth process. It consists initially of the formation of nuclei at the cathode surface followed by their growth to larger crystals. The two processes occur simultaneously with different velocities. If the rate of nuclei formation is more than the crystal growth, the deposit obtained is fine grained whereas if the crystal growth is more rapid, it favours cluster formation and the deposit is coarse, non-uniform and unsatisfactory.

Composition of the bath has marked effects on the relative velocities of nuclei formation and on their subsequent crystal growth. The cathode polarization and the structure of the deposit also play their own role. It would appear that for the production of a rapid and thick deposit, the presence of a large number of metallic ions in the electrolytic is desirable, but this would favour rather the rapid growth of a few crystals than the production of a large number of small crystals, which is the characteristic of a fine grained deposit. On the other hand if dilute solutions are used, the passage of a current soon removes the metal ions present near the cathode and burnt, spongy deposits results. Agitation of the solution would bring the other metal

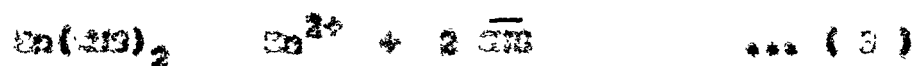
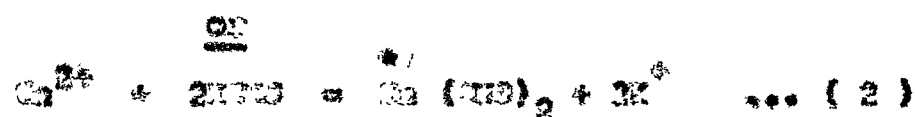
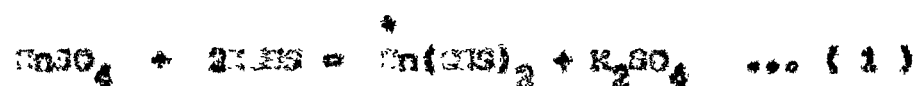
ions nearer to the cathode but at the same time it stirs the sludge that is invariably found at the bottom of the bath. This precipitate settles on the cathode and makes the deposit rough and uneven. Hence the use of dilute solutions with agitation is not desirable. Therefore, an ideal bath composition (electrolyte concentration) would be one containing a few metal ions but plenty of dissolved metal salt to furnish a fresh supply of ions as fast as they are removed. The solution of a complex salt of the metal satisfies this condition. The complex ionizes in two or more stages, the metal usually being ionized at the last stage and to a limited extent. This means that the rate of formation of nuclei is actually decreased by increasing the concentration of the dissolved metal salt in presence of a ligand like alkali thiocyanide added in the bath. The ions are made available for discharge at the cathode as and when required and thus a uniform adherent deposit would result. The resulting complexes containing largely the zinc metal ions in the form of  $Zn(CN)_2$  or  $Zn(CN)_3^-$  and others hitherto unknown, might get formed. Thiocyanide ions are bound up with zinc. We have however <sup>no</sup> specific evidence for the formation of different types of complexes to attain equilibrium. As such we have to depend on the meagre data available with us indicating the formation of the following types of complexes with known instability constants  $\beta$  and  $\beta'$  for overall complex and the others for stepwise dissociation complexes.



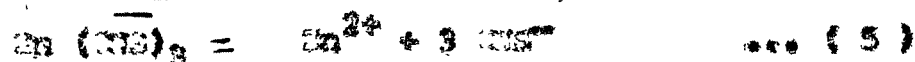
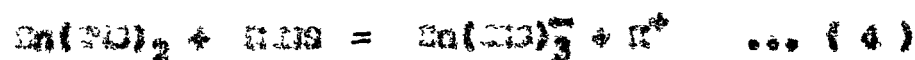
The high sulphocyanide concentration gives maximum conductivity and also provides largely as a complexing ion in solubilizing Zn (SCN)<sub>2</sub> forming complex salts of probable compositions. The most important variables in controlling the formation of specific complexes are the pH and the thiocyanate content of the bath. The complexes of the types mentioned may be supposed to dissociate as follows :

Zn-Complexes ( Thiocyanate bath ) :

The reactions that are believed to occur may be summarized as follows :



\* Equilibrium or Dissociation constant being not very low ( about  $10^{-10}$  ) may yield a complex Zn (SCN)<sub>3</sub> as follows :



Zn<sup>2+</sup> either from (3) or (5) gets reduced at the cathode



The further growth of deposit follows the laws of adsorption.

Some parts of the cathode are deposited by fresh metal ions for their turn to be discharged.

Tin Complexes ( Acid Chloride Bath ) :

The reactions that are believed to occur may be summarized as follows :

Stannous and Stannic Complexes :



OR



OR



$\text{Sn}^{2+}$  produced from feeble dissociation of the complex as in (1a)' or (2a)', gets reduced at the cathode as :



Alternatively, as the both edges and the stannous tin oxides, higher complexes due to the availability of d orbitals, get formed and the coordination number increases from four to six. Thus, stannic complexes may be envisaged.

